## (19) World Intellectual Property Organization International Bureau





## (43) International Publication Date 18 September 2003 (18.09.2003)

## **PCT**

# (10) International Publication Number WO 03/077037 A1

(51) International Patent Classification: G03F 7/20

(21) International Application Number: PCT/EP03/01954

(22) International Filing Date: 26 February 2003 (26.02.2003)

(25) Filing Language: English

(26) Publication Language: English

(30) Priority Data: 102 10 899.4 8 March

8 March 2002 (08.03.2002) DE

- (71) Applicant: CARL ZEISS SMT AG [DE/DE]; Carl-Zeiss-Strasse 22, 73447 Oberkochen (DE).
- (72) Inventors: ROSTALSKI, Hans-Jürgen; Albertinenstrasse 56, 13086 Berlin (DE). ULRICH, Wilhelm; Lederackerring 44, 73434 Aalen (DE).
- (74) Agent: PATENTANWÄLTE RUFF, WILHELM, BEIER, DAUSTER & PARTNER; ZUSAMMEN-SCHLUSS NR. 16, Kronenstrasse 30, 70174 Stuttgart (DE).

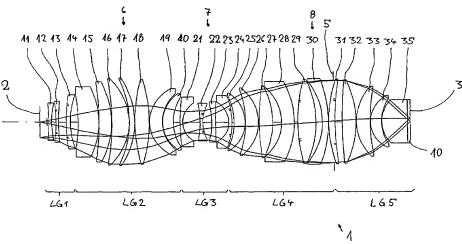
- (81) Designated States (national): AE, AG, AL, AM, AT, AU, AZ, BA, BB, BG, BR, BY, BZ, CA, CH, CN, CO, CR, CU, CZ, DK, DM, DZ, EC, EE, ES, FI, GB, GD, GE, GH, GM, HR, HU, ID, IL, IN, IS, JP, KE, KG, KP, KR, KZ, LC, LK, LR, LS, LT, LU, LV, MA, MD, MG, MK, MN, MW, MX, MZ, NO, NZ, OM, PH, PL, PT, RO, RU, SC, SD, SE, SG, SK, SL, TJ, TM, TN, TR, TT, TZ, UA, UG, UZ, VC, VN, YU, ZA, ZM, ZW.
- (84) Designated States (regional): ARIPO patent (GH, GM, KE, LS, MW, MZ, SD, SL, SZ, TZ, UG, ZM, ZW), Eurasian patent (AM, AZ, BY, KG, KZ, MD, RU, TJ, TM), European patent (AT, BE, BG, CH, CY, CZ, DE, DK, EE, ES, FI, FR, GB, GR, HU, IE, IT, LU, MC, NL, PT, SE, SI, SK, TR), OAPI patent (BF, BJ, CF, CG, CI, CM, GA, GN, GQ, GW, ML, MR, NE, SN, TD, TG).

#### **Published:**

- with international search report
- before the expiration of the time limit for amending the claims and to be republished in the event of receipt of amendments

[Continued on next page]

#### (54) Title: REFRACTIVE PROJECTION OBJECTIVE FOR IMMERSION LITHOGRAPHY



(57) **Abstract:** A purely refractive projection objective suitable for immersion microlithography is designed as a single-waist system with five lens groups, in the case of which a first lens group with a negative refracting power, a second lens group with a positive refracting power, a third lens group with a negative refracting power, a fourth lens group with a positive refracting power and a fifth lens group with a positive refracting power are provided. The system aperture is in the region of maximum beam diameter between the fourth and the fifth lens group. Embodiments of projection objectives according to the invention achieve a very high numerical aperture of NA > 1 in conjunction with a large image field, and are distinguished by a good optical correction state and moderate overall size. Pattern widths substantially below 100 nm can be resolved when immersion fluids are used between the projection objective and substrate in the case of operating wavelengths below 200 nm.



## WO 03/077037 A1



For two-letter codes and other abbreviations, refer to the "Guidance Notes on Codes and Abbreviations" appearing at the beginning of each regular issue of the PCT Gazette.

## Description

## Refractive projection objective for immersion lithography

The invention relates to a refractive projection objective for projecting a pattern arranged in an object plane of the projection objective into an image plane of the projection objective with the aid of an immersion medium which is arranged between a last optical element of the projection objective and the image plane.

Photolithographic projection objectives have been in use for several 10 decades for producing semiconductor components and other finely structured structural elements. They serve the purpose of projecting patterns of photomasks or reticles, which are also denoted below as masks or reticles, onto an object coated with a photosensitive layer with very high resolution on a reducing scale. 15

Three developments running in parallel chiefly contribute to the production of every finer structures of the order of magnitude of 100 nm or below. Firstly, an attempt is being made to increase the image-side 20 numerical aperture (NA) of the projection objective beyond the currently customary values into the region of NA=0.8 or above. Secondly, ever shorter wavelengths of ultraviolet light are being used, preferably wavelengths of less than 260 nm, for example 248 nm, 193 nm, 157 nm or below. Finally, still other measures are being used to increase resolution, for example phase-shifting masks and/or oblique illumination.

In addition, there are already approaches to improving the achievable resolution by introducing an immersion medium of high refractive index into the space between the last optical element of the projection objective and the substrate. This technique is denoted here as immersion lithography. Introducing the immersion medium yields an effective wavelength of

25

30

$$\lambda_{\rm eff} = \lambda_0/n$$
,

 $\lambda_0$  being the vacuum operating wavelength and n the refractive index of the immersion medium. This yields a resolution of

5

$$R = k_1 (\lambda_{eff}/NA_0)$$

and a depth of focus (DOF) of

10 DOF = 
$$\pm k_2 (\lambda_{eff}/NA_0^2)$$
,

 $NA_0$  = sin  $\Theta_0$  being the "dry" numerical aperture, and  $\Theta_0$  being half the aperture angle of the objective. The empirical constants  $k_1$  and  $k_2$  depend on the process.

15

20

The theoretical advantages of immersion lithography reside in the reduction of the effective operating wavelength and the resolution improved thereby. This can be achieved in conjunction with an unchanged vacuum wavelength, and so established techniques for producing light for selecting optical materials, for coating technology etc. can be adopted largely without change for the appropriate wavelength. However, measures are required for providing projection objectives with very high numerical apertures in the region of NA = 1 or above. Furthermore, suitable immersion media must be available.

25

30

The article entitled "Immersion Lithography at 157 nm" by M. Switkes and M. Rothschild, J. Vac. Sci. Technol. Vol. 19 (6), Nov./Dec. 2001, pages 1 ff. presents immersion fluids based on perfluoropolyethers (PFPE) which are sufficiently transparent for a working wavelength of 157 nm and are compatible with some photoresist materials currently being used in microlithography. One tested immersion fluid has a

refractive index of n = 1.37 at 157 nm. The publication also describes a lens-free optical system, operating with calcium fluoride elements and silicon mirrors, for immersion interference lithography, which is intended to permit the projection of 60 nm structures and below in conjunction with a numerical aperture of NA = 0.86. The optical system may not be suitable for use in the series production of semiconductors or the like.

Patent Specification US 5,610,683 (corresponding to EP 0 605 103) describes a projection exposure machine, provided for immersion lithography, having devices for introducing immersion fluid between the projection objective and the substrate. No design is specified for the optical projection system.

US Patent US 5,900,354 proposes using a super-critical fluid, for example xenon gas, as immersion medium in immersion lithography. No design is shown for a suitable projection objective.

15

It is the object of the invention to create a refractive projection objective which is suitable for immersion lithography and which has, in conjunction with a moderate overall size, a high numerical aperture suitable for immersion lithography, an image field which is sufficiently large for practical use in wafer steppers or wafer scanners, and a good correction state.

- This object is achieved by means of a projection objective having the features of Claim 1. Advantageous embodiments are specified in the dependent claims. The wording of all the claims is incorporated in the description by reference.
- In accordance with one aspect of the invention, a refractive projection objective for projecting a pattern arranged in an object plane of the projection objective into the image plane of the projection objective with

the aid of an immersion medium which is arranged between a last optical element of the projection objective and the image plane has a first lens group, following the image plane, with a negative refracting power;

a second lens group, following thereupon, with a positive refracting power;

10

15

25

30

a third lens group, following thereupon, with a negative refracting power; a fourth lens group, following thereupon, with a positive refracting power; a fifth lens group, following thereupon, with a positive refracting power; and

a system aperture which is arranged in the region of maximum beam diameter between the fourth lens group and the fifth lens group.

This refracting power distribution produces a projection objective having two bellies and a waist therebetween, a good correction of the field curvature thereby being achieved. The system aperture is seated in the region of greatest beam diameter of the belly next to the image plane, preferably at least 90% or 95% of the maximum beam diameter being present in the belly near the image at the location of the system 20 aperture. In certain embodiments, the system aperture can lie between a plane of maximum beam diameter near the image and the image plane, and thus in a region in which the transilluminated diameter of the objective already decreases towards the image plane. This is a substantial difference from conventional, refractive projection objectives in which the system aperture lies on the object side at a relatively large distance in front of the region of maximum beam diameter in the belly near the image.

The design permits image-side numerical apertures NA ≥ 0.9, it being possible in the case of preferred embodiments to achieve NA = 1.1 or above. Preferred projection objectives are adapted to an immersion fluid which has a refractive index of n > 1.3 at the operating wavelength. As a result, a reduction in the effective operating wavelength by 30% or more can be achieved by a comparison with systems without immersion.

The projection objective can advantageously be designed such that the space to be filled up by the immersion medium has an axial thickness which is so small that transmission losses in the immersion medium are no more than 10 to 20% of the penetrating light intensity. Consequently, image-side working distances of less than 200 μm, in particular less than 100 μm, are favourable. Since, on the other hand, touch contact between the last optical element and the substrate surface is to be avoided, a lower limit for the working distance of from 10 to 20 μm should not be undershot. Larger working distances in the region of one or more millimeters are also possible given suitably transparent immersion media.

15

Preferred projection objectives are distinguished by a number of favourable structural and optical features which are necessary alone or in combination for the suitability of the objective as an immersion objective.

20

25

30

For example, it can be favourable when the refracting powers of the lens groups are of the same order of magnitude on both sides of the system aperture. In particular, it can be provided that a ratio between the focal length of the fourth lens group and the focal length of the fifth lens group is between approximately 0.9 and approximately 1.1. It can likewise be favourable when the focal lengths or refracting powers of the lens groups near the object and lens groups near the image are similar in magnitude. In particular, a ratio of the magnitudes of the focal lengths of the first lens group and the fifth lens group can be between approximately 0.7 and approximately 1.3, preferably between approximately 0.9 and 1.1. Furthermore, it can be favourable for

producing a high image-side numerical aperture when a strong positive refracting power is concentrated in the region near the image. In preferred embodiments, a ratio between the overall length of the projection objective and the focal length of the fifth lens group following the system aperture is greater than five, in particular greater than six, seven or even eight. The axial distance between the object plane and image plane is denoted here as overall length.

10

25

In order to achieve a good correction state, it is provided in preferred embodiments that the first lens group includes at least one aspheric surface. Favourably, it is even possible for a plurality of aspherics, for example two, to be provided here. Aspherics in this region make a particularly effective contribution to the correction of distortion and astigmatism. It is favourable, furthermore, for the correction of coma and astigmatism when the third lens group, situated in the region of the waist, has at least one aspheric surface, a plurality of aspherics, for example two aspherics, being preferred. In the case of preferred embodiments, at least one aspheric is provided in each lens group in order to facilitate fine setting of the correction state of the projection 20 objective. With regard to simple production of the lenses, the number of aspherics should be limited, for example to less than nine or less than seven, as in the case of a preferred embodiment.

The favourable projection properties of projection objectives according to the invention, particularly the good correction state in the case of a very high numerical aperture, are promoted by some special features relating to the type and arrangement of the lenses used. For example, it is favourable when at least one meniscus lens, convex relative to the object plane, with a negative refracting power is arranged in the near zone of the object plane, in particular in the first lens group. This lens, which can form the third lens of the objective, for example, favours the correction of tangential astigmatism.

The second lens group preferably has at least one, in particular a plurality of meniscus lenses, concave relative to the object plane, with a positive refracting power on its side facing the object plane. These preferably combine with at least one, preferably a plurality of meniscus lenses, convex relative to the object plane, with a positive refracting power on the side, facing the image plane, of the second lens group. At least one biconcave positive lens is favourably situated between the menisci or meniscus groups of the opposing bending. As a result, a sequence of at least one positive meniscus lens, concave relative to the object plane, a biconvex positive lens and at least one positive meniscus lens, concave relative to the image plane, can be formed in the second lens group. This sequence of lenses in the region of relatively large beam diameter of the first belly is favourable for a strong "deformation" of the main ray in this region in conjunction with low areal stresses of the optical surfaces. This is favourable for low total aberrations of the projection objective. A favourable areal stress in the sense of this application occurs whenever the incidence angles of the rays striking an optical surface are as small as possible and do not overshoot a critical limit value. Denoted here as incidence angle is the angle between the impingement direction of a ray on an optical surface and the surface normal of the optical surface at the impingement point of the ray. The smaller the incidence angle and, correspondingly, the lower the areal stress, the easier is the development of suitable antireflection coatings, and the greater is the tolerance of the design to the adjustment.

25

10

15

20

The region of narrowest constriction of the ray is denoted as the waist. The third lens group in the region of the waist has the task of reexpanding the radiation, converging downstream of the first belly, with as few aberrations as possible. It is favourable for this purpose when the third lens group has only lenses with a negative refracting power. It has proved to be particularly advantageous when, with reference to a plane of symmetry lying inside the third lens group, the third lens group is of

substantially symmetrical construction. This is distinguished, in particular, by virtue of the fact that mutually assigned lenses of the same type are arranged on the object side and image side of the plane of symmetry. The symmetry of the lens types preferably also extends into the bordering region of the second and fourth lens groups such that an exit region, facing the third lens group, of the second lens group, and an entry region, following the third lens group, of the fourth lens group can be constructed substantially symmetrically relative to the plane of symmetry lying inside the third lens group. A symmetrical arrangement of negative and positive meniscus lenses will be explained in further detail in conjunction with the embodiments. The symmetry promotes a low areal stress of the lenses in conjunction with few aberrations.

At least one doublet with a biconvex positive lens and a meniscusshaped negative lens, following towards the image, with lens surfaces which are concave towards the object is preferably provided in the region directly upstream of the system aperture, that is to say in the fourth lens group. Particularly favourable are embodiments having two such doublets which can follow one another directly. A positive air lens, 20 convex relative to the image plane, is respectively arranged between the lenses of the doublet. Such doublets composed of a collecting biconvex lens and a diverging meniscus have a positive effect on the correction state and can counteract the aberrations which are introduced by lenses with a strong, positive diffracting power downstream of the system aperture. It can be favourable, moreover, to arrange in the object-side entry region of the fourth lens group at least one meniscus lens, concave towards the object, with a positive refracting power, in order to collect the radiation coming from the waist in conjunction with a low areal stress.

30

25

10

In order to achieve very high numerical apertures, it is advantageous when the fifth lens group has exclusively positive lenses. It is possible,

for example, to arrange four or more positive lenses between aperture stop and image plane. In this case, favourable surface loads can be achieved whenever at least one meniscus lens, concave towards the image, with a positive refracting power is provided in the fifth lens group. In particular, two or more such lenses can be provided. The last optical element is preferably formed by a plano-convex lens which preferably has a spherical entry surface and a substantially flat exit surface. It is possible thereby, on the one hand, to achieve a good correction of spherical aberration and coma and, on the other hand, a substantially 10 flat exit surface is favourable for immersion lithography. In preferred embodiments, the plano-convex lens is nonhemispherical, the centre of the spherical surface lying outside the lens. Truncated hemispherical lenses of this type can yield a reduced sensitivity to fluctuations in the working distance.

15

30

By applying some or all of these design principles, success has been achieved in preferred embodiments which keep the surface loads of the lenses so low that despite an aperture of more than NA = 0.9 or 1, incidence angles whose sine is greater than approximately 90% or even 20 approximately 85% of the image-side numerical aperture do not occur at any of the optical surfaces, and this simplifies the coating of the lenses and the adjustment of the objective.

In preferred embodiments, all the lenses of the projection objective consist of the same material. For operating wavelengths of 193 nm, synthetic quartz glass and, for operating wavelengths of 157 nm, calcium fluoride can be used, for example, as material. The use of only one kind of material facilitates production and permits simple adaptation of the objective design to other wavelengths. It is also possible to combine a plurality of kinds of material in order, for example, to support the correction of chromatic aberrations. It is also possible to use other UV-transparent materials such as BaF<sub>2</sub>, NaF, LiF, SrF, MgF<sub>2</sub> or the like.

In addition to the claims, the description and the drawings also disclose the preceding and further features, it being possible for the individual features to be implemented on their own or severally in the form of subcombinations in the case of embodiments of the invention and in other fields, and for them to constitute advantageous designs which can be protected per se. In the drawings:

Figure 1 shows a lens section through a first embodiment of a refractive projection objective which is designed for a 193 nm operating wavelength;

10

15

- Figure 2 shows a lens section through a second embodiment of a projection objective which is designed for a 193 nm operating wavelength;
- Figure 3 shows a lens section through a third embodiment of a projection objective which is designed for a 157 nm operating wavelength; and
- 20 Figure 4 shows a lens section through a fourth embodiment of a projection objective which is designed for a 193 nm operating wavelength.

25 axis" denotes a straight line through the centres of curvature of the optical components. Directions and distances are described as on the image side or towards the image when they are aligned in the direction of the image plane or the substrate, which is to be exposed, located there, and as on the object side or towards the object when they are directed towards the object with reference to the optical axis. In the examples, the object is a mask (reticle) with the pattern of an integrated circuit, but it can also be another pattern, for example a grating. In the

examples, the image is formed on a wafer which serves as a substrate and is provided with a photoresist layer, but other substrates are also possible for example elements for liquid crystal displays or substrates for optical gratings. The focal lengths specified are focal lengths with reference to air.

Identical or mutually corresponding features of the various embodiments are denoted below with the same reference symbols for reasons of clarity.

10

15

20

25

30

A typical design of an embodiment of a purely refractive reduction objective 1 according to the invention is shown with the aid of Figure 1. It serves the purpose of projecting in conjunction with virtually homogeneous immersion a pattern, arranged in an object plane 2, of a reticle or the like into an image plane 3 to a reduced scale, for example to the scale of 5:1. This is a rotationally symmetrical single-waist system with five lens groups which are arranged along the optical axis 4, which is perpendicular to the object plane and image plane, and form an object-side belly 6, an image-side belly 8 and a waist 7 situated therebetween. The first lens group LG1, following the image plane 2, has a negative refracting power and a focal length of -166 mm. A second lens group LG2, following thereupon, has a positive refracting power with a focal length of 121 mm. A third lens group LG3, following thereupon, has a negative refracting power and a focal length of -33 mm. A fourth lens group LG4, following thereupon, has a positive refracting power with a focal length of 166 mm, which therefore corresponds in terms of magnitude to the focal length of the first lens group. A fifth lens group LG5, following thereupon, has a positive refracting power and a focal length of 170 mm, which is of the order of magnitude of the focal length of the fourth lens group and of the first lens group LG1 in terms of magnitude. The system aperture 5 is arranged between the fourth lens group LG4 and the fifth lens group LG5 in the

region, near the image, of maximum beam diameter, that is to say in the second belly 8 of the objective.

The first lens group LG1, following the object plane 2, is substantially responsible for the expansion of the light bundle into the first belly 6. It comprises three lenses 11, 12, 13 with a negative refracting power, the first lens 11 and the second lens 12 being configured as biconvex negative lenses. The third lens 13 is a diverging meniscus in the case of which as a special feature the concave side is directed not towards the object 2 but towards the image plane 3. This arrangement is very favourable for correcting the tangential astigmatism. Otherwise, the first lens group includes two aspherics, specifically the entry sides of the second and the third lens. The aspherics have a positive influence on the very good correction of the distortion and the astigmatism.

The second lens group LG2 comprises four collecting menisci 14, 15, 16, 17, facing the reticle or the object plane 2 with their concave side, a biconvex positive lens 18 and two collecting menisci 19, 20 facing the wafer or the image plane 3 with their concave side. This design, in which the curvatures of the meniscus surfaces run on the object side and image side of the biconvex lens 18 in opposite directions with concave surfaces averted from one another, ensures small areal stresses for the menisci and the positive lens 18, and thus few aberrations. The biconcave air lens between the biconvex positive lens 18 and the following meniscus lens 19 has with its strong astigmatic undercorrection a favourable influence on the balancing-out of the astigmatism in the front part of the system upstream of the waist 7.

The third lens group LG3 consists exclusively of diverging lenses, specifically a negative meniscus lens 21 with image-side concave surfaces, a biconcave negative lens 22, following thereupon, a further biconcave negative lens, following thereupon, and a negative meniscus lens 24, following thereupon, with object-side concave surfaces. With

30

reference to a plane of symmetry 9 lying between the lenses 22 and 23, these four lenses are designed with mirror symmetry with regard to lens type (meniscus lens or biconcave lens) and direction of curvature of the optical surfaces. Together with the last two lenses 19, 20 of the second lens group and the first two lenses 25, 26 of the fourth lens group LG4, following thereupon, there is a series of two collecting menisci 19, 20 and one diverging meniscus 21, all three of which have concave surfaces facing the waist or the plane of symmetry 9. In the opposite, mirrored direction, that is to say on the image side of the plane of symmetry 9, the two biconcave negative lenses 22, 23 are again followed at the waist, that is to say in the area of smallest diameter, by a diverging meniscus 24 and two collecting menisci 25, 26 of the fourth lens group. This design having mirror symmetry relative to the plane of symmetry 9 supports a low tensioning or a low areal stress of the optical surfaces, and thus few aberrations.

10

15

20

25

The third lens group includes, in the form of the exit surface of the smallest lens 22 and the exit surface of the negative meniscus lens 24, two aspherics which make a substantial contribution to the correction of the coma and the astigmatism.

The fourth lens group LG4 comprises on its entry side two positive meniscus lenses 25, 26 which are concave relative to the object plane and are followed by two doublets 27, 28 and 29, 30. Each of the doublets has, on the object side, a collecting biconvex lens 27 and 29, respectively, and downstream thereof a diverging meniscus 28 and 30, respectively, whose concave surfaces point towards the object plane. The two spherically strongly overcorrected, diverging menisci 28 (f' = -728 mm) and 30 (f' = -981 mm) counteract the strongly undercorrected, collecting lenses of the fifth lens group LG5 following downstream of the system aperture 5. The combination of the collecting biconvex lens and the diverging meniscus inside a doublet has a very positive effect on the

correction of image errors in the region of the second belly 8. With their strong overcorrection of the tangential astigmatism, the two menisci 28, 30, in particular the thick meniscus 28, counteract the undercorrection in the fifth lens group LG5.

5

15

The fifth lens group LG5, situated downstream of the system aperture 5, is substantially responsible for producing the high numerical aperture. Provided for this purpose are exclusively collecting lenses, specifically a positive meniscus lens 31, arranged in the region of the system aperture 5, with surfaces concave towards the image, a biconvex positive lens 32, following thereupon, with a slightly curved entry side and a more strongly curved exit side, a positive meniscus lens 23, following thereupon, with surfaces concave towards the image, a further positive meniscus lens 24, likewise with surfaces concave towards the image, and a terminating plano-convex lens 35 with a spherical entry side and a flat exit side. The positive lenses 31, 32, 33 and 34 are strongly undercorrected spherically and overcorrected with reference to the coma. In the case of this design, the correction of the spherical aberration and the coma is therefore implemented substantially in conjunction with the configuration of the 20 fourth lens group LG4 which is situated upstream of the system aperture 5 and creates a corresponding offset of these aberrations.

Consequently, the fourth lens group LG4 and the fifth lens group LG5 are responsible in combination for achieving a good correction state of the spherical aberration and of coma. An aspheric surface on the entry 25 side of the biconvex lens 27 of the first doublet substantially supports the correction of the spherical aberration, but also of the coma of third order. An aspheric surface, arranged in the vicinity of the system aperture 5, on the exit side of the positive meniscus lens 31, convex towards the object, at the input of the fifth lens group LG5 chiefly corrects aberrations of 30 higher order and thereby makes a substantial contribution to setting a good aberration compromise. A likewise positive influence on the

correction of aperture aberration and coma is exerted by the spherical, convex entry surface of the plano-convex lens 35. The latter is spherically overcorrected and undercorrected with reference to coma.

The system has a working distance on the image side of approximately 5 8.4 mm, which can be filled up by an immersion fluid 10. Deionized water (refractive index n = 1.47) or another suitable transparent liquid, for example, can be used at 193 nm as immersion fluid.

The correction state of the optical system 1 is excellent. All aberrations 10 are corrected. The RMS value of the wavefront deformation is very low at 4 m $\lambda$ . The distortion of all field points in the region is below 1 nm. A projection objective is thus created which operates at an operating wavelength of 193 nm, can be produced with the aid of conventional techniques for lens production and coating, and permits a resolution of structures substantially below 100 nm.

The design described is fundamentally suitable for near-field lithography, as well, by the use of a homogeneous immersion. For this purpose, the terminating plano-convex lens 35 is to be combined with the immersion layer 10 to form a lens which can consist, for example, of synthetic quartz glass. In order to permit sufficient light energy of the evanescent field to be coupled in, in this case the working distance between the exit surface of the projection objective and the image plane should be in the region of 100 nm or below.

25

30

The specification of the design is summarized in a known way in tabular form in Table 1. Here, column 1 gives the number of a refracting surface, or one distinguished in another way, column 2 gives the radius r of the surface (in mm), column 3 gives the distance d denoted as thickness, of the surface from the following surface (in mm), column 4 gives the material of the optical components, and column 5 gives the refractive

index of the material of the component, which follows the entry surface. The useful, free radii or half the free diameter of the lenses (in mm) are specified in column 6.

In the case of the embodiment, six of the surfaces, specifically the surfaces 4, 6, 15, 29, 34 and 44, are aspheric. Table 2 specifies the corresponding aspheric data, the aspheric surfaces being calculated using the following rule:

10  $p(h)=[((1/r)h^2)/(1+SQRT(1-(1+K)(1/r)^2h^2))]+C1*h^4+C2*h^6+...$ 

Here, the reciprocal (1/r) of the radius specifies the surface curvature, and h the distance of a surface point from the optical axis.

Consequently, p(h) gives the so-called sagitta, that is to say the distance of the surface point from the surface apex in the z direction, that is to say in the direction of the optical axis. The constants K, C1, C2, ... are reproduced in Table 2.

The optical system 1, which can be reproduced with the aid of these

data, is designed for an operating wavelength of approximately 193 nm,
for which the synthetic quartz glass used for all the lenses has a
refractive index n = 1.56029. The image-side numerical aperture is 1.1.
The system is adapted to a refractive index of the immersion medium 10
of n = 1.56, which permits a virtually ideal coupling of the light into the
immersion layer 10. The objective has an overall length (distance
between image plane and object plane) of 1162 mm. A light
conductance (product of numerical aperture and image size, also
denoted étendue or geometrical flux) of 24.1 mm is achieved given an
image size of 22 mm.

30

A variant of the projection objective shown in Figure 1 is explained with the aid of Figure 2. Lenses or lens groups of the same type or the same

function are denoted by the same reference symbols for reasons of clarity. The system 1' is optimized for a refractive index of the immersion medium of n = 1.37, and this corresponds to a value, which has become known from the literature, of 157 nm for the refractive index of an immersion fluid based on perfluoropolyether (PFPE).

10

25

The fourth and the fifth lens group differ in terms of design from that in accordance with Figure 1. In LG4, the thick meniscus lens 28 of the first doublet in Figure 1 is split up into an object-side, biconcave negative lens 28' with an only slightly curved exit side and a subsequent biconvex positive lens 28" with a correspondingly only slightly curved entry side. This splitting-up further reduces the areal stress of the optical surfaces in this region. The rim ray of the projection runs in a converging fashion in the air space between the subsequent lenses 29, 30 upstream of the entry surface of the meniscus 30 which is concave towards the object. In the fifth lens group LG5, the entry-side lenses 31, 32, separated in the case of the design in Figure 1 and downstream of the system aperture 5 are combined to form a single, biconvex positive lens 32'. This is situated at a distance downstream of the system aperture 5, which can 20 be accessed particularly easily. A further special feature consists in that the system aperture 5 is situated between a plane, near the image, of maximum beam diameter and the image plane 3, that is to say where the transilluminated diameter of the lenses already decreases towards the image plane. The other lenses correspond with regard to the type and sequence of the lenses of identical reference symbols in Figure 1. In the case of this design, as well, all the lenses consist of synthetic quartz glass. The specification of this design in the notation described is specified in Tables 3 and 4.

Shown in Figure 3 is a third embodiment, designed for an operating 30 wavelength of 157 nm, of a projection objective 1" whose specification is given in Tables 5 and 6. It is to be seen from the sequence and the type

of lenses that the design is based on the design principle explained with the aid of Figures 1 and 2, and so the same reference symbols are used for lenses and lens groups with corresponding functions. As in the case of the embodiment in accordance with Figure 1, no further optical element is arranged upstream of the first biconcave negative lenses 11 of the objective. As in the case of the embodiment in accordance with Figure 2, in the fourth lens group LG4 the thick meniscus lens 28, still in one piece in Figure 1, is split up into a biconcave negative lens 28' and a directly following biconvex positive lens 28". Just as in the case of the embodiment in accordance with Figure 2, the function of the entry-side lenses 31, 32 of the embodiment in accordance with Figure 1 is taken over by a single, biconvex positive lens 32' which initiates the ray combination towards the image plane. In a way similar to the case of the embodiment in accordance with Figure 2, the system aperture 5 is situated inside the second belly 8 downstream of the region of maximum beam diameter, that is to say where the beam diameter already decreases again towards the image plane.

The refractive index for the immersion medium is set at n = 1.37, which corresponds to a value, which has become known from the literature, for a PFPE-based immersion fluid sufficiently transparent at 157 nm. The image-side working distance is set to approximately 50  $\mu$ m, which corresponds in practical use to the thickness of the immersion layer. It may be assumed that suitable immersion fluids still have high transmission values of more than 90% in the case of this low thickness, and so only negligible, low transmission losses occur in the region of the immersion, this being favourable for achieving a satisfactory wafer throughput. Pattern widths of less than 70 nm can be resolved with the aid of this purely refractive projection objective, of excellent correction state, which can be implemented using conventional means.

20

30

Tables 7 and 8 show the specification of an embodiment (not illustrated pictorially) of a projection objective which is derived from the embodiment in accordance with Figure 3, from which it differs essentially in that the thick meniscus lens 17, concave towards the object, there is replaced by a thinner meniscus lens curved in the same direction. A comparison of Tables 5 and 6 shows that as a result an even more compact design is possible which has smaller lens diameters and a smaller overall length in conjunction with equally good optical properties.

A fourth embodiment of a projection objective 1", which is designed for 10 an operating wavelength of 193 nm and whose specification is given in Tables 9 and 10 is shown in Figure 4. This embodiment has a projection scale of 4:1 and an image-side numerical aperture NA = 0.9. A comparison with the remaining embodiments shows that less lens material is required in conjunction with the same fundamental optical principle. Instead of 25, as in the case of the other embodiments, there is a need for only 23 lenses, and moreover the average and maximum lens diameters are smaller than with the preceding embodiments. In particular, there is provision in the second lens group LG2 for only three 20 menisci 14, 15, 16, concave towards the object, a lens corresponding to the menisci 17 of the other embodiments being absent. In contrast to the other embodiments, in the fourth lens group LG4 only one doublet 27 and 28 is provided, and so a saving of one lens is made in this lens group as well. The symmetrical design of the third lens group LG3 and of the lens pairs bordering thereon, 19, 20, of the second lens group and 25 25, 26 of the fourth lens group corresponds to that of the other embodiments. The embodiment in accordance with Figure 4 substantiates that it is also possible to implement solutions of favourable design within the scope of the invention for relatively large projection 30 scales and relatively large fields.

The correction state of all the embodiments shown is excellent. All aberrations are corrected. The maximum RMS value of the wavefront deformation is very low and is below  $4.5 \text{ m}\lambda$  for the embodiments in accordance with Figures 1 and 2, below  $6.5 \text{ m}\lambda$  for the embodiment in accordance with Tables 7 and 8, and below  $5.2 \text{ m}\lambda$  for the embodiment in accordance with Figure 4. Within all the systems, the distortion is in the region below 1 nm for all field points.

It can be seen by the person skilled in the art from the examples that
numerous modifications of the designs are possible within the scope of
the invention. For example, individual lenses can be split up into two or
more separate lenses, or separate lenses can be combined to form a
single lens having essentially the same function.

- Embodiments with two or more lens materials are also possible. For example, in the case of embodiments for 193 nm it is possible to provide a combination of lenses made from synthetic quartz glass and calcium fluoride in order to facilitate chromatic correction and in order to avoid changes in refractive index because of compaction in regions of high radiation energy densities by using calcium fluoride lenses. Also possible is the use of other materials transparent to the ultraviolet light used, such as barium fluoride, sodium fluoride, lithium fluoride, strontium fluoride, magnesium fluoride or the like.
- 25 Catadioptric systems for immersion lithography can also be designed using essential configuration features of the embodiments represented here, in particular in the region, near the image, of the second belly and the aperture stop.
- The technical teaching of the invention explained with the aid of various exemplary embodiments shows that a range of design boundary

conditions should be taken into account when the aim is to design an optical system suitable for immersion lithography, particularly one of such compact design. The following features can be beneficial individually or in combination. Immersion objectives for which the image field diameter is greater than approximately 1%, in particular greater than approximately 1.5% of the overall length are favourable. Favourable light conductances (product of image field diameter and numerical aperture) are in the region of above 1%, in particular above 2% of the overall length. Four or more collecting lenses between aperture stop and image plane are favourable, it being preferred for only collecting lenses to be provided in this region. Preferably more than four, five or six consecutive collecting lenses are favourable in the second lens group. In this case, preferably two or more collecting menisci with an object-side concave surface are favourable in the entry region of the second lens group, and two or more collecting menisci with surfaces 15 concave towards the image are favourable at the end of the second lens group. In the region of the first belly or of the second lens group a strong beam expansion is beneficial for which the maximum beam diameter is preferably more than 1.8 times, in particular more than 2 times the object field diameter. The maximum lens diameter in the second lens group 20 can be approximately twice the minimum free lens diameter of the third lens group in the region of the constriction. The maximum lens diameter in the second belly following the constriction is preferably of the same order of magnitude and can, in particular, be greater than twice the 25 minimum free diameter in the third lens group. In the region of the third lens group, that is to say in the region of the waist of the system, two concave surfaces are preferably directly opposite one another and are enclosed by two surfaces curved in the same sense. The lenses respectively adjoining towards the object and towards the image are also preferably designed and arranged in this way. 30

Particular lens distributions can be favourable. In particular, it is favourable when substantially more lenses are situated upstream of the system aperture than downstream of the aperture. The number of lenses upstream of the aperture is preferably at least four times, in particular more than five times, the number of lenses downstream of the system aperture. Five or more collecting lenses are preferably arranged between the region of narrowest constriction and the system aperture or aperture stop; the axial distance between the region of narrowest constriction and the aperture stop arranged exceptionally near the image is favourably at least 26%, if appropriate more than 30% or 35%, of the overall length of the projection objectives.

10

15

20

25

30

Further special features relate to the trajectory of and the relationships between principal rays and rim rays of the projection. Denoted here as principal ray is a ray which runs from a rim point of the object field parallel or at an acute angle to the optical axis and which cuts the optical axis in the region of the system aperture. A rim ray in the sense of the present application leads from the middle of the object field to the rim of the aperture stop. The perpendicular distance of these rays from the optical axis yields the corresponding ray height. It can be favourable when the principle ray height is greater in absolute value up to the end of the second lens group than the rim ray height, this relationship preferably not being reversed until in the region of the third lens group. The maximum rim ray height is preferably more than twice, in particular more than 2.3 to 2.5 times, the rim ray height in the region of the narrowest constriction of the third lens group. It is favourable when the diameter of the rim ray is kept small in the region between the fourth and fifth lens groups, that is to say in the region of the system aperture. This corresponds to a smallest possible focal length of the fifth lens group, following the system aperture. The focal length of the fifth lens group is preferably smaller than 15%, in particular smaller than 10% of the overall length. Preferred systems are doubly telecentric, and so the principal ray

is substantially perpendicular both to the object plane and to the image plane. In preferred systems, the principal ray coming from the object field should still have a divergent trajectory after at least five lenses, that is to say a trajectory with a still rising principal ray height away from the optical axis. It is favourable, furthermore, when the sine of the maximum principal ray divergence angle in the objective region near the object is more than 50% of the object-side numerical aperture. A plurality of aspheric surfaces are preferably provided in the region near the object in which the rim ray height is greater than the principal ray height, in order to promote a favourable correction state.

The invention also relates to a projection exposure machine for microlithography which is distinguished in that it includes a refractive projection objective in accordance with the invention. The projection exposure machine preferably also has devices intended for introducing and keeping an immersion medium, for example a liquid of suitable refractive index, between the last optical surface of the projection objective and the substrate to be exposed. Also covered is a method for producing semiconductor components and other finely structured structural elements, in the case of which an image of a pattern arranged in the object plane of a projection objective is projected in the region of the image plane, an immersion medium arranged between the projection objective and the substrate to be exposed and transparent to light at the operating wavelength being transilluminated.

10

15

20

Table 1

SURFACE   RADII						
0				151050	REFRACTIVE INDEX	1/2 FREE
1 C.00000000 S 45-565462 2 -697.373131352 6.830738619 S102 1.56028900 60.6 3 17.877790816 12.366856184 4 -389.517361474AS 6.912967568 S102 1.56028900 65.3 5 664.978777634 23.692566944 6 612.579041806AS 12.565039007 S102 1.56028900 66.3 7 315.238108546 24.055777166 92.5 8 -636.903175512 64.773662854 S102 1.56028900 95.3 9 -204.036729565 1.00000000 120.5 10 -942.407223561 39.155776761 S102 1.56028900 95.3 11 -317.623154272 1.312033169 137.65028900 145.5 12 -856.579380710 53.692176363 S102 1.56028900 145.5 13 -222.120764338 1.000000000 145.5 13 -222.120764338 1.000000000 146.6 14 -365.979641333 16.565547178 S102 1.56028900 146.5 15 -300.375347712 1.000000000 146.6 622.472470310 44.751302453 S102 1.56028900 146.5 17 -556.306013695 1.020913522 1.56028900 146.5 18 135.290972565 40.672419816 S102 1.56028900 146.5 19 140.238400611 1.007703555 1.002 1.56028900 97.0 21 178.381821741 21.317336106 97.2 22 764.210626300 8.040530767 S102 1.56028900 97.0 23 81.619567541 55.11180427 66.0 24 -275.984672757 12.121405585 S102 1.56028900 97.0 26 -275.984672757 12.121405585 S102 1.56028900 97.0 27 2685.503343355 41.843073620 68.3 28 -271.500870518AS 7.122879020 310.2 1.56028900 97.3 30 -234.0682816820 34.813633391 S102 1.56028900 97.3 31 -128.675213398 1.375380851 9.10294676 S102 1.56028900 97.3 31 -128.675213398 1.375380851 9.10294876 S102 1.56028900 97.3 31 -139.5228408611 9.10662930 S102 1.56028900 97.3 31 -139.52384888 9.102888 9.102888 9.102988 9.10288 9.10288 9.10288 9.10288 9.10288 9.10288 9.10288 9.10288 9.10288 9.10288 9.10288 9.1028 9.10288 9.10288 9.10288 9.10288 9.1028 9.1028 9.1028 9.1028 9.10	URFACE	RADII	THICKNESSES	LENSES	193.304 nm	DIAMETER
1 C.00000000 S 36566462 2 -697.373131352 6.830738619 S102 1.56028900 60.6 3 17.877790816 12.366856184 4 -389.517361474AS 8.012967568 S102 1.56028900 65.3 5 664.978717634 23.693566944 6 612.579041806AS 12.565039007 S102 1.56028900 66.3 7 315.238108546 24.056777166 92.5 8 -636.903175512 64.776662854 S102 1.56028900 95.3 9 -204.036729565 1.00000000 120.5 10 -942.407223581 39.155776761 S102 1.56028900 95.3 11 -317.623154272 1.312033169 12.565028900 137.6 12 -856.5779360710 53.693176363 S102 1.56028900 145.5 13 -222.120764338 1.000000000 145.5 13 -222.120764338 1.000000000 146.6 14 -365.979641333 16.565547178 S102 1.56028900 146.6 15 -300.375347712 1.000000000 150.6 16 622.472470310 44.791302453 S102 1.56028900 146.5 17 -556.306013695 1.070913522 1.56028900 146.5 19 140.228400611 1.007703555 1.00200000 13.5 19 140.228400611 1.007703555 1.00200000 13.5 20 128.146489274 33.605830320 S102 1.56028900 97.0 21 178.381821741 21.317336106 97.2 22 764.210626300 8.040530767 S102 1.56028900 97.0 23 81.619567541 55.11180427 66.0 24 -275.984672757 12.121405585 S102 1.56028900 97.0 26 -275.984672757 12.121405585 S102 1.56028900 97.0 27 2685.503343355 41.883073620 62.5 28 -83.042453444 9.216662930 S102 1.56028900 97.0 29 -271.500870518AS 7.122879020 12.56028900 12.7 31 -158.555144143 2.1426588 S102 1.56028900 12.7 32 684.565103122AS 42.656894678 S102 1.56028900 12.7 33 -636.340504AS 29.11662930 S102 1.56028900 12.7 34 -324.577506735 8.010204876 S102 1.56028900 12.7 35 -371.070689222 40.564766288 S102 1.56028900 12.7 36 -371.070689228 40.564768288 S102 1.56028900 12.7 37 -365.355614473 2.1426585 S102 1.56028900 12.7 38 -63.0625571533 56.787878605 S102 1.56028900 12.7 39 -271.500070518AS 7.122879020 12.56028900 12.7 30 -234.062816820 34.813633391 S102 1.56028900 12.7 31 -158.555144143 2.1426585 S102 1.56028900 12.7 31 -158.555144143 2.1426585 S102 1.56028900 12.7 31 -158.555144143 2.1426585 S102 1.56028900 12.7 31 -316.315520885 10.9136677 S102 1.56028900 12.7 31 -316.315520885 10.9136677 S102 1.56028900 12.7 31 -460.148730628 6.645		0 00000000	21 660160000			EE 000
2 -697.373131352 6.530736619 S102 1.56028900 60.6 3						
3 317.877790816 12.366856184 4 -389.517361474AS 8.012967568 SIO2 1.56028900 65.2 5 684.978717634 23.691566944 70.0 6 612.5790412806AS 12.565039007 SIO2 1.56028900 66.3 7 315.238108546 24.056777166 92.5 8 -636.903175512 64.77662854 SIO2 1.56028900 95.1 9 -104.036729565 1.306000000 120.0 10 -942.407223581 39.153776761 SIO2 1.56028900 130.7 11 -317.623154272 1.332033169 137.6 12 -856.579360710 51.6593176363 SIO2 1.56028900 145.5 13 -222.120764338 1.000000000 148.6 14 -365.979641333 16.5655547178 SIO2 1.56028900 146.3 15 -300.375347712 1.000000000 148.6 16 622.472470310 44.791302453 SIO2 1.56028900 146.3 17 -556.306013695 1.020913522 1.56028900 146.3 18 135.290972565 40.672419816 SIO2 1.56028900 145.5 19 140.238400611 1.007703555 99.3 20 128.146489274 33.605830320 SIO2 1.56028900 97.0 21 178.381821744 12.307336106 97.2 22 764.210626300 8.040530767 SIO2 1.56028900 85.3 23 81.619567541 55.11180427 66.2 24 -725.984572757 12.121405585 SIO2 1.56028900 69.2 25 -275.984572757 12.121405585 SIO2 1.56028900 90.3 26 -275.984572757 12.121405585 SIO2 1.56028900 12.7 27 2685.503343355 41.843073620 90.2 28 -83.024436344 9.216662930 SIO2 1.56028900 90.3 29 -271.500870518AS 7.122879020 90.3 30 -234.062816820 34.8313633391 SIO2 1.56028900 12.7 31 -128.679213398 1.375380851 90.2 1.56028900 12.7 31 -128.679213398 1.375380851 90.2 1.56028900 12.7 31 -128.679213398 1.375380851 90.2 1.56028900 12.7 31 -128.679213398 1.375380851 90.2 1.56028900 12.7 31 -128.679213398 1.375380851 90.2 1.56028900 12.7 31 -128.679213398 1.375380851 90.2 1.56028900 12.7 31 -128.679213398 1.375380851 90.2 1.56028900 12.7 31 -128.679213398 1.375380851 90.2 1.56028900 12.7 31 -128.679213398 1.375380851 90.2 1.56028900 12.7 31 -128.679213398 1.375380851 90.2 1.56028900 12.7 31 -128.679213398 1.395380851 90.2 1.56028900 12.7 31 -128.679213398 1.395380851 90.2 1.56028900 12.7 31 -136.315520485 10.983607088 SIO2 1.56028900 12.7 31 -136.91520485 10.983607088 SIO2 1.56028900 12.7 31 -148.679213398 10.993607088 SIO2 1.56028900 12.7 31 -158.655571533 56.788789605 SIO2 1				9102	1 56029500	
4         -389.51736147AS         8.012967568         SIO2         1.56028900         65.2           5         684.978717634         23.693566944         70.0         66.2         70.0         66.2         70.0         66.2         70.0         66.2         70.0         66.2         70.0         66.2         70.0         66.2         70.0         66.2         70.0         66.2         70.0         66.2         70.0         66.2         70.0         66.2         70.0         66.2         70.0         66.2         70.0         66.2         70.0         95.1         70.0				5102	1.30028300	
6         64.978717634         23.693566944         70.0           6         612.579041806AS         13.563639007         \$102         1.56028900         66.3           7         315.238108546         24.059777166         92.5         92.5         92.5           8         -636.903175512         64.773662854         \$102         1.56028900         95.1           9         -304.036729565         1.300000000         120.5         130.7           10         -942.407223581         39.153776761         \$102         1.56028900         130.7           11         -317.623154272         1.312033169         137.6         137.6         137.6           12         -856.579360710         \$3.659176363         \$102         1.56028900         148.6           14         -365.979641333         16.00000000         148.6         148.6           15         -300.375347712         1.000000000         148.6         622.472470310         44.751302453         \$102         1.56028900         146.3           17         -556.360613695         1.029913522         1         156028900         135.5           18         135.290972565         40.672419816         \$102         1.56028900         13.5	-			6703	3 55338000	
6 612.579941806AS 12.565C39007 SIO2 1.56028900 92.5 8 -636.903175512 64.773662854 SIO2 1.56028900 95.1 9 -304.036729565 1.000000000 120.5 10 -942.407223581 39.155776761 SIO2 1.56028900 130.7 11 -317.623154272 1.312033169 13.56028900 146.5 13 -222.120764338 1.000000000 148.6 14 -365.979641333 16.565547178 SIO2 1.56028900 148.6 15 -300.375347712 1.000000000 150.6 16 622.472470310 44.791302453 SIO2 1.56028900 146.5 17 -556.306013695 1.020913522 145.5 18 135.290972565 40.672419816 SIO2 1.56028900 146.5 19 140.228400611 1.007703555 99.2 20 128.164689274 33.605830320 SIO2 1.56028900 97.6 21 178.381821741 21.367336106 37.5 22 764.210626300 8.040530767 SIO2 1.56028900 65.3 81.619567541 55.11180427 66.6 25 133.065440504AS 29.116630876 6.2 26 -275.984572757 12.121405585 SIO2 1.56028900 69.3 27 2685.503343355 41.843073620 SIO2 1.56028900 69.3 28 -83.024363434 9.316662930 SIO2 1.56028900 69.3 30 -234.082816820 34.813633391 SIO2 1.56028900 69.3 31 -128.679213398 1.375380851 99.3 31 -128.679213398 1.37538067028 91.2 32 -371.0000000000 1.566533351 91.2 33 -156028900 122.7 34 -16034626687 40.277028630 SIO2 1.56028900 122.7 35 -293.770426726 28.164927093 91.2 36 -170.081620687 40.277028630 SIO2 1.56028900 122.7 37 -316.315520485 10.9888667028 SIO2 1.56028900 144.5 41 -460.148730828 16.485394474 91.48596028 91.48594474 91.48596028 91.48594474				2102	1.56028900	
7 315.238108546 24.05577166 92.5 8 -636.903175512 64.775662854 SIO2 1.56028900 95.1 9 -304.0367729565 1.006000000 120.5 10 -942.407223581 39.153776761 SIO2 1.56028900 137.6 11 -317.623154272 1.312033169 137.6 12 -856.579360710 53.658176363 SIO2 1.56028900 146.5 13 -222.120764338 1.000000000 148.6 14 -365.979641333 16.565547178 SIO2 1.56028900 148.6 15 -300.375347712 1.000000000 150.6 16 622.472470310 44.791302453 SIO2 1.56028900 146.5 17 -556.306013695 1.020913522 145.3 18 135.290972565 40.672419816 SIO2 1.56028900 146.5 19 140.238400611 1.007703555 99.2 20 128.146489274 33.605830320 SIO2 1.56028900 97.6 21 178.381821741 21.367336106 37.5 27 764.210626300 8.040530767 SIO2 1.56028900 85.3 28 133.065440504AS 29.116630876 SIO2 1.56028900 63.6 29 -275.984572757 12.121405585 SIO2 1.56028900 63.6 29 -271.500870518AS 7.122879020 63.2 20 -234.062816820 34.813633391 SIO2 1.56028900 99.3 31 -128.679213398 1.375380851 99.3 32 -371.070689222 40.964768288 SIO2 1.56028900 99.3 33 -158.555144143 2.142646331 34 844.565103125AS 42.656894678 SIO2 1.56028900 122.7 35 -293.770426726 28.164927093 SIO2 1.56028900 122.7 36 -170.081620687 40.277028630 SIO2 1.56028900 122.7 36 -170.081620687 40.277028630 SIO2 1.56028900 122.7 37 -316.315520485 10.94366728 SIO2 1.56028900 122.7 38 623.625571531 S6.6789788605 SIO2 1.56028900 122.7 39 -171.500870518AS 7.122879020 90.3 30 -234.062816820 34.813633391 SIO2 1.56028900 122.7 31 -128.679213398 1.375380851 99.64768288 SIO2 1.56028900 122.7 32 -171.500870518AS 7.122879020 90.3 31 -128.679213398 1.375380851 12.75580851 12.756028900 143.3 34 844.565103125AS 42.656894678 SIO2 1.56028900 143.3 35 -170.081620687 40.277028630 SIO2 1.56028900 143.3 36 -170.081620687 40.277028630 SIO2 1.56028900 143.3 37 -316.315520485 10.94366728 SIO2 1.56028900 143.3 38 -1646893444 90.277028630 SIO2 1.56028900 143.3 39 -179.372716473 20.156523351 40.465394474 144.5				CTOS	1 55000000	70.051
8         -636,903175512         64.775662854         SIO2         1.56028900         95.1           9         -304.036729565         1.000000000         120.5         120.5           10         -942.407223581         39.153776761         SIO2         1.56028900         137.6           11         -317.623154272         1.312033169         137.6         137.6         137.6           12         -856.579360710         53.698176363         SIO2         1.56028900         148.6           14         -365.979641333         16.565547178         SIO2         1.56028900         148.6           15         -300.37547712         1.00000000         150.6         122.472470310         44.791302453         SIO2         1.56028900         146.3           16         622.472470310         44.791302453         SIO2         1.56028900         146.3           17         -556.306013695         1.027913552         1         1.56028900         145.3           18         135.299072565         40.672419816         SIO2         1.56028900         133.6           19         140.238400611         1.007703555         99.2         1         176.3628900         97.2           21         176.3628764         55.1				\$102	1.56028900	
9 -304.036729565 1.00000000 120.2 10 -942.407223581 39.153776761 SIO2 1.56028500 130.7 11 -317.623154272 1.312033169 137.8 12 -856.579360710 53.693176363 SIO2 1.56028900 145.5 13 -222.120764338 1.000000000 148.6 14 -365.979641333 16.565547178 SIO2 1.56028900 148.6 15 -300.375347712 1.000000000 150.6 16 622.472470310 44.791502453 SIO2 1.56028900 146.3 17 -556.306013695 1.020933522 145.3 18 135.290972565 40.672419816 SIO2 1.56028900 133.5 19 140.238400611 1.007703555 99.3 20 128.146489274 33.605830320 SIO2 1.56028900 97.6 21 178.381821741 21.367336106 37.5 22 764.210626300 8.040530767 SIO2 1.56028900 85.3 23 81.619567541 55.13180427 66.6 24 -324.577506735 8.010204876 SIO2 1.56028900 65.3 25 133.065440504AS 29.116630876 62.5 26 -275.984572757 12.12405585 SIO2 1.56028900 69.3 27 2685.503343355 41.843073620 62.5 28 -83.024363434 9.316662930 SIO2 1.56028900 69.3 30 -234.082816820 34.813633391 SIO2 1.56028900 12.7 31 -128.679213398 1.375380851 98.6 29 -271.500870518AS 7.122879020 93.3 31 -128.679213398 1.375380851 16.02 1.56028900 12.7 33 -158.555144143 2.142646331 16.02 1.56028900 12.7 34 844.565103125AS 42.656894678 SIO2 1.56028900 12.7 35 -293.770426726 28.164927093 SIO2 1.56028900 12.7 36 -170.081620687 40.9767288 SIO2 1.56028900 12.7 37 -316.315520485 10.983607028 13.7 38 623.625571533 56.79879850S SIO2 1.56028900 12.7 39 -375.372716473 20.156323351 16.02 1.56028900 12.7 30 -246.931005408 18.587257168 SIO2 1.56028900 12.7 31 -128.679213398 1.375380851 16.465394474 14.546394474 14.546394474 14.546394474 14.546394474 14.546394474 14.546394474 14.546394474 14.546391474 14.546391474 14.546391474 14.546391474 14.546391474 14.546391474 14.546391474 14.54639160 14.419956468931AS 22.930981004 14.4.54639160 14.4.54639160 14.4.54639160 14.4.54639160 14.54639160 14.54639160 14.546399160 14.54639160 14.54639160 14.556399100 14.55639900 14.55639900 14.55639900 14.55639900 14.55639900 14.55639900 14.55639900 14.55639900 14.55639900 14.55639900 14.55639900 14.55639900 14.55639900 14.55639900 14.55639900 14.55639900 14.55639900				0.4.0.0	1 55000000	92.585
10				\$102	1.56026900	95.153
137.623154272						120.585
12       -856.579360710       53.698176363       SIO2       1.56028900       148.6         13       -222.120764338       1.000000000       148.6         14       -365.979641333       16.565547178       SIO2       1.56028900       148.6         15       -300.375347712       1.000000000       150.0       150.0         16       622.472470310       44.791302453       SIO2       1.56028900       146.3         17       -556.360613695       1.020913522       145.3       145.3       181.56028900       113.5         18       135.290972565       40.672419816       SIO2       1.56028900       13.5       19.2         20       128.146489274       33.605830320       SIO2       1.56028900       87.5       19.2         21       178.381821741       21.347336106       36.6028900       85.3       87.5       87.5         22       764.210626300       8.040530767       SIO2       1.56028900       85.3       86.2         23       81.619567541       55.11180427       66.2       62.5       62.5       62.5         24       -324.577506735       8.010204876       SIO2       1.56028900       63.4         25       133.065440504AS				\$102	1.56028900	130.798
13       -222.120764338       1.000000000       148.4         14       -365.979641333       16.565547178       S102       1.56028900       148.6         15       -300.375347712       1.000000000       150.6       150.6       150.6       150.6       150.6       150.6       150.6       150.6       166.2       1.56028900       146.3       17.56028900       146.3       145.3       145.3       145.3       145.3       145.3       145.3       145.3       145.3       145.3       145.3       145.3       145.3       145.3       146.3						137.817
14       -365.979641333       16.565547178       S102       1.56028900       148.6         15       -300.375347712       1.00000000       150.0       150.0         16       622.472470310       44.791302453       S102       1.56028900       145.3         17       -556.306013695       1.020913522       145.3         18       135.290972565       40.672419816       S102       1.56028900       113.5         19       140.238400611       1.007703555       99.2       128.146489274       33.605830320       S102       1.56028900       97.0         21       178.381821741       21.367336106       87.5			53.698176363	\$102	1.56028900	145.587
15       -300.375347712       1.000000000       150.0         16       622.4772470310       44.751302453       S102       1.56028900       146.3         17       -556.306013695       1.029313522       1.56028900       113.5         18       135.290972565       40.672419816       S102       1.56028900       113.5         19       140.238400611       1.007703555       99.3         20       128.146489274       33.605830320       S102       1.56028900       87.5         21       178.381821741       21.347336106       87.5       87.5         22       764.210626300       8.040530767       S102       1.56028900       85.3         23       81.619567541       55.11180427       66.2       62.5         24       -324.577506735       8.010204876       S102       1.56028900       63.6         25       133.065440504AS       29.116630876       62.5         26       -275.984572757       12.12405585       S102       1.56028900       63.6         27       2685.503343355       41.843073620       80.2       1.56028900       69.3         29       -271.500870518AS       71228879020       80.2       1.56028900       69.3 <td></td> <td></td> <td>1.00000000</td> <td></td> <td></td> <td>148.413</td>			1.00000000			148.413
16       622.472470310       44.791302453       8102       1.56028900       146.3         17       -556.360613695       1.020913522       145.3       145.3         18       135.290972565       40.672419816       SIO2       1.56026900       131.5         19       140.238400611       1.007703555       99.3         20       128.146489274       33.605880320       SIO2       1.56028900       97.0         21       178.381821741       21.367336106       87.9       66.0         22       764.210626300       8.040530767       SIO2       1.56028900       85.3         23       81.619567541       55.11180427       66.0         24       -324.577506735       8.010204876       SIO2       1.56028900       63.5         25       133.06544050488       29.116630876       62.5       62.5         26       -275.984572757       12.121405585       SIO2       1.56026900       63.5         27       2685.503343355       41.893073620       68.1       62.5         28       -83.024363434       9.216662930       SIO2       1.56028900       69.2         29       -271.50087051885       7.122879020       90.3         31	. 4	-365.979641333	16.565547178	S102	1.56028900	148.696
17       -556.306013695       1.020913522       145.2         18       135.290972565       40.672419816       SIO2       1.56026900       113.5         19       140.238400611       1.047703555       99.2       1.56028900       97.0         20       128.146489274       33.605830320       SIO2       1.56028900       97.0         21       178.381821741       21.367336106       87.9       66.0         22       764.210626300       8.040530767       SIO2       1.56028900       65.3         23       81.619567541       55.111180427       66.0       62.5         24       -324.577506735       8.010204876       SIO2       1.56028900       63.6         25       133.065440504A8       29.116630876       62.5       62.5         26       -275.984572757       12.121405585       SIO2       1.56028900       63.6         27       2685.503343355       41.843073620       68.1         28       -83.024363434       9.316662930       SIO2       1.56028900       69.3         29       -271.500870516AS       7.122879020       90.3       90.3         30       -234.082816820       34.813633991       SIO2       1.56028900       192.7			1.000000000			150.000
18         135.290972565         40.672419816         SIO2         1.56026900         113.6           19         140.238400611         1.007703555         99.3           20         128.146489274         33.605830320         SIO2         1.56028900         97.6           21         178.381821741         21.347336106         87.9         87.9           22         764.210626300         8.040530767         SIO2         1.56028900         85.3           23         81.619567541         55.11180427         66.2         62         62           24         -324.577506735         8.010204876         SIO2         1.56028900         63.6           25         133.065440504AS         29.116630876         62.5         62.5           26         -275.984572757         12.12405585         SIO2         1.56026900         63.6           27         2685.503343355         41.843073620         68.1           28         -83.024363434         9.216662930         SIO2         1.56028900         69.3           29         -271.500870518AS         1.22879020         30         -234.082816820         34.813633391         SIO2         1.56028900         93.1           31         -128.679213398	. 6	622.472470310	44.791302453	S102	1.56028900	146.389
18       135.299972565       40.672419816       SIO2       1.56026900       113.5         19       140.238400611       1.007703555       1.56028900       97.6         20       128.146489274       33.605830320       SIO2       1.56028900       97.6         21       178.381821741       21.367336106       87.5       87.5         22       764.210626300       8.040530767       SIO2       1.56028900       85.3         23       81.619567541       55.131180427       66.6       62.5         24       -324.577506735       8.010204876       SIO2       1.56028900       63.4         25       133.065440504AS       29.116630876       62.5       62.5         26       -275.984572757       12.121405585       SIO2       1.56028900       63.4         27       2685.503343355       41.843073620       80.2       1.56028900       69.3         29       -271.500870518AS       7.122879020       90.3       90.3         30       -234.082816820       34.813633391       SIO2       1.56028900       93.1         31       -128.679213398       1.375380851       98.6       1.2       1.56028900       122.7         33       -158.555144143 </td <td>.7</td> <td>-556.306013695</td> <td>1.020913522</td> <td></td> <td></td> <td>145.384</td>	.7	-556.306013695	1.020913522			145.384
15       140.238400611       1.607703555       99.5         20       128.146489274       33.605830320       \$102       1.56028900       97.6         21       178.381821741       21.367336106       87.9       87.6         22       764.210626300       8.040530767       \$102       1.56028900       85.3         23       81.619567541       55.11180427       66.6       66.6         24       -324.577506735       8.010204876       \$102       1.56028900       63.6         25       133.065440504AS       29.116630876       62.5         26       -275.984572757       12.121405585       \$102       1.56026900       63.5         27       2685.503343355       41.893073620       68.1       68.1         28       -83.024363434       9.216662930       \$102       1.56026900       69.3         29       -271.500870518AS       7.122879020       90.3         30       -234.062816820       34.813633191       \$102       1.56028900       93.1         31       -128.679213398       1.375380851       98.6       12.7         32       -371.070689222       40.964768288       \$102       1.56028900       122.7         35	. 8	135.290972565	40.672419816	S102	1.56028900	113.552
2C       128.146489274       33.605830320       \$102       1.56028900       97.6         21       178.381821741       21.367336106       87.5       87.5         22       764.210626300       8.040530767       \$102       1.56028900       85.3         23       81.619567541       55.111180427       66.0         24       -324.577506735       8.010204876       \$102       1.56028900       63.6         25       133.065440504A8       29.116630876       62.5         26       -275.984572757       12.121405585       \$102       1.56026900       63.6         27       2685.503343355       41.893073620       68.1         28       -83.024363434       9.216662930       \$102       1.56028900       69.3         29       -271.500870518AS       7.122879020       90.3       90.3         30       -234.082816820       34.813633391       \$102       1.56028900       93.1         31       -128.679213398       1.375380851       98.6         32       -371.070689222       40.564765288       \$102       1.56028900       122.7         33       -158.555144143       2.142646331       1.56028900       122.7         35       -293.7	.9	140.238400611	1.007703555			99.382
21       178.381821741       21.367336106       87.5         22       764.210626300       8.040530767       SIO2       1.56028900       85.3         23       81.619567541       55.11180427       66.6       66.2         24       -324.577506735       8.010204876       SIO2       1.56028900       63.6         25       133.065440504AS       29.116630876       62.5         26       -275.984572757       12.12405585       SIO2       1.56026900       63.5         27       2685.503343355       41.843073620       68.1         28       -83.024363434       9.216662930       SIO2       1.56028900       69.3         29       -271.500870518AS       7.122879020       90.3         30       -234.082816820       34.813633391       SIO2       1.56028900       93.1         31       -128.679213398       1.375380851       98.6         32       -371.070689222       40.964766228       SIO2       1.56028900       122.7         33       -158.555144143       2.142646331       1.60       122.7         34       844.565103125AS       42.658894678       SIO2       1.56028900       122.7         35       -293.770426726       2	2 C	128.146489274		S102	1.56028900	97.047
22     764.210626300     8.040530767     SIO2     1.56028900     85.2       23     81.619567541     55.11180427     66.0       24     -324.577506735     8.010204876     SIO2     1.56028900     63.6       25     133.0654405048     29.116630876     62.5       26     -275.984572757     12.12405585     SIO2     1.56026900     63.5       27     2685.503343355     41.893073620     68.1       28     -83.024363434     9.216662930     SIO2     1.56028900     69.3       29     -271.500870518AS     7.122879020     90.3       30     -234.082816820     34.813633191     SIO2     1.56028900     69.3       31     -128.679213398     1.375380851     98.6       32     -371.070689222     40.964766288     SIO2     1.56026900     122.7       33     -158.555144143     2.142646331     1.60     1.56026900     122.7       34     844.565103125AS     42.656894678     SIO2     1.56028900     123.0       35     -293.770426726     28.164927093     123.3       36     -170.081620687     40.277928630     SIO2     1.56028900     122.7       37     -316.315520485     10.983607028     137.1       38 <td>21</td> <td>178.301821741</td> <td></td> <td></td> <td></td> <td>87.913</td>	21	178.301821741				87.913
23       81.619567541       55.11180427       66.0         24       -324.577506735       8.010204876       SIO2       1.56028900       63.4         25       133.065440504AS       29.116630876       62.5       62.5         26       -275.984572757       12.121405585       SIO2       1.56026900       63.5         27       2685.503343355       41.893073620       68.1         28       -83.024363434       9.216662930       SIO2       1.56028900       69.3         29       -271.500870518AS       7.122879020       90.3         30       -234.082816820       34.813633391       SIO2       1.56028900       93.1         31       -128.679213398       1.375380851       98.6         32       -371.070689222       40.564766288       SIO2       1.56028900       122.7         33       -158.555144143       2.142646331       1.56028900       123.6         34       844.565103125AS       42.656894678       SIO2       1.56028900       123.6         35       -293.770426726       28.164927093       123.6       123.3         36       -170.081620687       40.277028630       SIO2       1.56028900       122.7         38 <t< td=""><td></td><td>764.210626300</td><td></td><td>S102</td><td>1.56028900</td><td>85.346</td></t<>		764.210626300		S102	1.56028900	85.346
24         -324.577506735         8.010204876         \$102         1.56028900         63.6           25         133.0654405048S         29.116630876         62.5           26         -275.984572757         12.12405585         \$102         1.56026900         63.5           27         2685.503343355         41.843073620         68.1           28         -83.024363434         9.216662930         \$102         1.56028900         69.3           29         -271.500870518AS         7.122879020         90.3         90.3         90.3           30         -234.082816820         34.813633391         \$102         1.56028900         93.1           31         -128.679213398         1.375380851         98.6           32         -371.070689222         40.964766228         \$102         1.56026900         122.7           33         -158.555144143         2.142646331         16.0         1.56028900         122.7           35         -293.770426726         28.164927093         \$102         1.56028900         122.7           36         -170.081620687         40.277028630         \$102         1.56028900         122.7           37         -316.315520485         10.943607028         \$102 <td< td=""><td></td><td></td><td></td><td></td><td></td><td>66.098</td></td<>						66.098
25     133.065440504AS     29.116630876     62.5       26     -275.984572757     12.121405585     SIO2     1.56026900     63.5       27     2685.503343355     41.883073620     681.5     682.5       28     -83.024363434     9.216662930     SIO2     1.56028900     69.3       29     -271.500870518AS     7.122879020     90.3       30     -234.082816820     34.8136331991     SIO2     1.56028900     93.1       31     -128.679213398     1.375380851     98.6       32     -371.070689222     40.964766288     SIO2     1.56026900     122.7       33     -158.555144143     2.142646331     116.0     1.56026900     122.7       34     844.565103125AS     42.656894678     SIO2     1.56026900     123.0       35     -293.770426726     28.164927093     123.3       36     -170.081620687     40.277028650     SIO2     1.56028900     122.7       37     -316.315520485     10.983607028     137.1       38     623.625571533     56.798798505     SIO2     1.56028900     143.3       39     -379.372716473     20.18532351     143.1       40     -246.931005408     18.567257168     SIO2     1.56028900     142.2 <td></td> <td></td> <td></td> <td>5102</td> <td>1 56028900</td> <td>63.499</td>				5102	1 56028900	63.499
26         -275.984572757         12.121405585         SIO2         1.56026900         63.5           27         2685.503343355         41.893073620         SIO2         1.56026900         69.3           28         -83.024363434         9.216662930         SIO2         1.56026900         69.3           29         -271.500870518AS         7.122879020         90.3           30         -234.082816820         34.813633391         SIO2         1.56026900         93.1           31         -128.679213398         1.375360851         98.6           32         -371.070689222         40.964766288         SIO2         1.56026900         112.7           33         -158.555144143         2.142646331         116.0         1.56028900         123.6           34         844.565103125AS         42.656894678         SIO2         1.56028900         123.6           35         -293.770426726         28.164927093         123.6         1.56028900         122.7           37         -316.315520485         10.943607028         10.943607028         137.1         1.56028900         122.7           38         623.625571533         56.798798605         SIO2         1.56028900         143.3           40				0102	1.50020500	
27       2685.503343355       41.843073620       68.1         28       -83.024363434       9.216662930       SIO2       1.56028900       69.3         29       -271.500870518AS       7.122879020       90.3       90.3         30       -234.082816820       34.813633391       SIO2       1.56028900       93.1         31       -128.679213398       1.375380851       98.6         32       -371.070689222       40.964766228       SIO2       1.56026900       122.7         33       -158.555144143       2.142646331       1.60       1.60         34       844.565103125AS       42.658894678       SIO2       1.56028900       122.7         35       -293.770426726       28.164927093       123.3       123.3         36       -170.081620687       40.277028630       SIO2       1.56028900       122.7         37       -316.315520485       10.943607028       137.1       136.315520485       10.943607028       137.1         38       623.625571533       56.788798605       SIO2       1.56028900       143.3         40       -246.931005408       18.567257168       SIO2       1.56028900       142.2         41       -469.91005408       18.56725				5102	1 56025900	
28       -63.024363434       9.216662930       SIO2       1.56028900       69.3         29       -271.500870518AS       7.122879020       90.3         30       -234.082816820       34.813633391       SIO2       1.56028900       93.1         31       -128.679213398       1.375380851       98.6       1.56026900       112.7         32       -371.070689222       40.964766288       SIO2       1.56026900       112.7         33       -158.555144143       2.142646331       116.0         34       844.565103125AS       42.656894678       SIO2       1.56028900       122.7         35       -293.770426726       28.164927093       123.3       123.3         36       -170.081620687       40.277028630       SIO2       1.56028900       122.7         38       623.625571533       56.788798505       SIO2       1.56028900       143.3         39       -379.372716473       20.155323351       143.1         40       -246.931005408       18.57257168       SIO2       1.56028900       142.2         41       -460.148730628       16.445394474       145.5       145.5         42       0.000000000       -15.465394474       14.56028900       144				3102	1.30026300	
29         -271.500870516AS         7.122879020         90.3           30         -234.082816820         34.813633291         SIO2         1.56028900         93.1           31         -128.679213398         1.375380851         98.6         98.6           32         -371.070689222         40.964766288         SIO2         1.56026900         112.7           33         -158.555144143         2.142646331         116.0         1.56028900         122.0           34         844.565103125AS         42.656894678         SIO2         1.56028900         122.0           35         -293.770426726         28.164927093         123.3         123.3           36         -170.081620687         40.277028650         SIO2         1.56028900         122.7           37         -316.315520485         10.983607028         137.1         1.56028900         122.7           38         623.625571533         56.798798605         SIO2         1.56028900         143.3           40         -246.931005408         18.587257168         SIO2         1.56028960         142.2           41         -460.148730628         16.485394474         145.5         145.5           42         0.000000000         -15.465394474				erna	1 56020000	
30				3102	1.36028300	
31     -128.679213398     1.375380851     90.6       32     -371.070689222     40.964766288     SIO2     1.56026900     112.7       33     -158.555144143     2.142646331     116.0       34     844.565103125A8     42.655894678     SIO2     1.56028900     123.0       35     -293.770426726     28.164927093     123.3       36     -170.081620687     40.277028630     SIO2     1.56028900     122.7       37     -316.315520485     10.983607028     137.1       38     623.625571533     56.798798505     SIO2     1.56028900     143.3       39     -379.372716473     20.156323351     143.1       40     -246.931005408     18.57257168     SIO2     1.56028900     142.2       41     -460.148730628     16.465394474     145.2       42     0.000000000     -15.465394474     144.3       43     506.946830874     18.875460558     SIO2     1.56028900     144.5       44     1011.956468931AS     22.938981004     144.5     144.5       45     1760.701259607     42.739861927     SIO2     1.56028900     143.5				6103	1 56026500	
32     -371.070689222     40.964766288     SIO2     1.56026900     112.7       33     -158.555144143     2.142646331     116.0       34     844.565103125A8     42.656894678     SIO2     1.56028900     123.3       35     -293.770426726     28.164927093     123.3       36     -170.081620687     40.277028630     SIO2     1.56028900     122.7       37     -316.315520485     10.983607028     38.625571533     56.798798605     SIO2     1.56028900     143.3       39     -179.372716473     20.155323351     143.1       40     -246.931005408     18.587257168     SIO2     1.56028960     142.2       41     -460.148730028     16.445394474     145.5       42     0.000000000     -15.465394474     144.3       43     506.946830874     18.875460558     SIO2     1.56028900     144.5       44     1011.956468931AS     22.938981004     144.5       45     1760.701259607     42.739861927     SIO2     1.56028900     144.5				3102	1.36028960	
33				CIOO	3 56036000	
34     844.56510312SAS     42.556894678     SIO2     1.56028900     123.3       35     -293.770426726     28.164927093     123.3       36     -170.081620687     40.277028630     SIO2     1.56028900     122.7       37     -316.315520485     10.943607028     137.1       38     623.625571533     56.798798505     SIO2     1.56028900     143.3       39     -379.372716473     20.156323351     143.1       40     -246.931005408     18.57257168     SIO2     1.56028900     142.2       41     -460.148730628     16.445394474     145.5       42     0.000000000     -15.445394474     144.3       43     506.946830874     18.875466558     SIO2     1.56028900     144.5       44     1011.956468931AS     22.930981004       45     1760.701259607     42.739861927     SIO2     1.56028900     143.5	-			5102	1.56028900	
35				0100		
36     -170.081620687     40.277028630     SIG2     1.56028900     122.7       37     -316.315520485     10.983607028     137.1       38     623.625571533     56.798798605     SIO2     1.56028900     143.3       39     -379.372716473     20.156323351     143.1       40     -246.931005408     18.567257168     SIO2     1.56028960     142.2       41     -460.1148730028     16.485394474     145.5       42     0.000000000     -15.465394474     144.3       43     506.946830874     18.875460558     SIO2     1.56028900     144.5       44     1011.956468931AS     22.930981004     144.1       45     1760.701259607     42.739861927     SIO2     1.56028900     144.5				2102	1.56028900	
37						
38 623.625571533 56.79879805 SIO2 1.56028900 143.3 39 -379.372716473 20.156323351 143.1 40 -246.931005408 18.587257168 SIO2 1.56028900 142.2 41 -460.148730628 16.485394474 145.2 42 0.000000000 -15.485394474 144.3 43 506.946830874 18.875460558 SIO2 1.56028900 144.5 44 1011.956468931AS 22.938981004 1760.701259607 42.739861527 SIO2 1.56028900 143.5				5102	1.56028900	122.713
39     -379.372716473     20.156323351     143.1       40     -246.931005408     18.567257168     SIO2     1.56028960     142.2       41     -460.1148730628     16.465394474     145.5       42     0.000000000     -15.465394474     144.3       43     506.946830874     18.875460558     SIO2     1.56028900     144.5       44     1011.956468931AS     22.930981004     144.1       45     1760.701259607     42.739861927     SIO2     1.56028900     143.5				aras	1 55000000	137.139
40     -246.931005408     18.567257168     SIO2     1.56028960     142.2       41     -460.148730628     16.445394474     145.5       42     0.000000000     -15.465394474     144.3       43     506.946830874     18.875460556     SIO2     1.56028900     144.5       44     1011.956468931AS     22.938981004     144.1     144.2       45     1760.701259607     42.739861927     SIO2     1.56028900     143.5				8102	1.56028900	143.361
41     -460.148730828     16.455394474     145.5       42     0.000000000     -15.465394474     144.3       43     506.946830874     18.875460556     SIO2     1.56028900       44     1011.956468931AS     22.938981004     144.5       45     1760.701259607     42.739861927     SIO2     1.56028900       143.5				a. a. a. a.		143.139
42 0.000000000 -15.465394474 43 506.946830874 18.875460556 5102 1.56028900 144.5 44 1011.956468931AS 22.938981004 144.1 45 1760.701259607 42.739861927 ST02 1.56028900 143.5				2103	1.56028900	142.262
43 506.946830874 18.875460558 SIO2 1.56028900 144.5 44 1011.956468931AS 22.930981004 144.1 45 1760.701259607 42.739861927 SIO2 1.56028900 143.5						145.978
44 1011.956468931AS 22.930981004 144.1 45 1760.701259607 42.739861927 STO2 1.56028900 143.5						144.329
45 1760.701259607 42.739861927 STO2 1.56028900 143.9				S102	1.56028900	144.915
						144.124
				S102	1.56028900	143.914
						143.620
	7		42.532993341	SIO2	1.56028900	120.019
48 689.962205932 1.126753967 114.5	E	689.962205932	1.126753967			114.927
	9	109.590774593	34.378356865	S102	1.56028900	88.972
	0					79.549
				S102	1.56028900	73.749
						19.439
		_				11.000

0.0000

-5.18910040e-009 3.51025484e-013 -5.47716488e-018 4.43561455e-023 3.42844064e-028

-1.97724021e-032 2.22456117e-037 0.00000000e+000 0.00000000e+000

## Table 2

#### ASPHERIC CONSTANTS

	201120	
SURF	ACE NO. 4	SURFACE NO.
к	0.0000	k 0.0
C1	2.13047921e-007	
C2	-3.57933301e-011	C2 3.5
C3	2.93263063e-015	C3 -5.4
C4	-4.61461071e-019	C4 4.4
C5	2.76861570e-023	C5 3.4
C6	1.62740830e-037	C6 -1.9
C7	-3.43732853e-031	C7 2.2
CB	0.0000000e+000	C8 0.0
C9	0.00000000e+000	°C9 0.0
SURF	ace no. $\epsilon$	
К	0.0000	
Cl	-1.14265623e-007	
C2	2.02166625e-011	
C3	-1.76403105e-015	
C4	2.36305340e-019	
C5	-2.55314839e-023	
C6	1.35459868e-027	
C7	-2.70730236e-032	
C8	0.00000000e+000	
C9	0.0000000e+000	
SURFA	CE NO. 25	
1/	0 0000	
K	0.0000	
Cl	-9.78914413e-CO8	
Ç2	-4.33168283e-012	
C3	-8.01001563e-017	
C4	-1.31611936e-019	
Ç5	6.54375176e-023	
C6	-1.37293557e-026	
C7	1.58764578e-030	
C8	0.000G0000e+C00	
C9	0.00000000000000	
SURF	ACE NO. 29	
ĸ	0.0000	
C1	2.99497807e-008	
C2	-3.16131943e-012	
C3	-9.61008384e-017	
C4	2.05647555e-020	
C5	-2.56167018e-024	
C6	1.74321022e-028	
C7	-7.59802684e-033	
C8	0.00000000e+000	
CS	0.000000000+000	
SURF	ACE NO. 34	
K	0.0000	
C1	-5.83593306e-009	
C2	-4.08253B93e-015	
C3	-3.40928951e-018	
C4	1.36466433e-022	
	-1.03090955e-026	
C5		
C.E	4.02018916e-031	
C?	-9.89543799e-036	
C8	0.00000000e+c00	
C9	0.00000000e+600	
-		

Table 3

SURFA	CE RADII	THICKNESSES	LENSES	REFRACTIVE INDEX ???.?? nm	1/2 FREE DIAMETER
0	0.00000000	21.986160000	L710	0.99988200	55.000
1	0.00000000	6.228362492	L710	0.99998200	59.974
2	-603.070624671	9.913063455	SIO2HL	1.56028900	60.690
3	280.916333783	13.300217883	HE193	0.99971200	64.385
4	-461.660931347AS	8.00000000	SIO2HL	1.56028900	65.798
5	681.261406487	25.180533824	HE193	0.99971200	70.487
6	421.796712825AS	13.410528997	SIC2HL	1.56028900	89.920
7	306.236502978	23.641054301	HE193	0.99971200	95.293
8	-881.743075988	64.144962259	SIO2HL	1.56028900	97.777
9	-397.616228767	1.032715630	HE193	0.99971200	123.195
10	-1049.995266970	39.473283137	SIO2HL	1.56028900	130.947
11	-286.549348161	2.251083978	HE193	0.99971200	136.447
12	-659.273684770	52.089256568	SIO2HL	1.56028900	143.894
13	-209.207390137	1.008491553	HE193	0.99971200	146.415
14	-565.795559961	15.829681399	s102 $H$ L	1.56028900	145.408
15	-410.848668817	1.000000613	HE193	0.99971200	146.045
16	809,207497255	27.599045382	SIO2HL	1.56028900	142.424
17	-599.260287529AS	1.000000015	HE193	0.99971200	141.453
18	136.304287826	42.528385200	SIO2HL	1.56028900	113.454
19	157.516637917	1.000000000	HE193	0.99971200	101-084
20	126.013978931	34.051407776	SIO2HL	1.56028900	96,007
21	157.519818688	23.554259229	HE193	0.99971200	84.914 ·
22	795.455608357	9.035828932	SIO2HL	1.56028900	82.369
23	78.918295716	30.235934318	HE193	0.99971200	63.551
24	-647.136797738	8.00000184	SIOZHL	1.56028900	63.056
25	148.158813477AS	32.440106724	HE193	0.99971200	61.484
26	-197.858636028	9.960377452	SIOSHL	1.56028900	62.472
27	1367.448704100	41.007582498	HE193	0.99971200	66.716
26	-87.255013445	8.475217865	SIOZHL	1.56028900	68.713
25	-396.760639119AS	6.473661900	HE193	0.99971200	88.202
30	-317.095597644	34.300021646	SIO2HL	1.56028900	90.935
31	-136.816156215	1.956487291	HE153	0.99971200	96.054
32	-384.621022314	38.250891268	SIO2HL	1.56028900	107.852
33	-156.063116797	1.000000006	HE193	0.99971200 1.56028900	111.057 117.589
34	507.690134076AS	41.496271568	. SIO2HL	0.99971200	117.901
35	-280.885163902	25.354810908	не193 S102HL	1.56028900	117.263
36 37	· -166.502630134 988.468038668	9.238823967	HE193	0.99971200	131.802
38	1106.583200370	6.683211723 44.085572378	SIOZHL	1.56028900	134.587
39	-353.437766566	1.000000005	HE193	0.99971200	136.483
40	445.624457242	52.624318854	SIO2HL	1.56028900	142.739
41	-460.556866224AS	26.188809880	HE193	0.99971200	142.372
42	-248.318425901	36.706472160	SIOZHL	1.56028900	141.622
43	-340.049722714AS	16.312593082	HE193	0.99971200	145.673
44	0.00000000	12.926710616	HE193	0.99971200	142.237
45	1026.963505660	42.907366082	SIO2HL	1.56028900	142.523
4 <del>6</del>	-417.465602619	1.875432853	HE193	0.99971200	142.184
47	189.021074062	41.889218814	SIO2HL	1.56028900	121.251
	698.095904580AS	1.076370948	HE193	0.99971200	117.434
48	109.988479121		SIO2HL	1.56028900	91.356
49		34.053123871	HE193	0.99971200	91.356 84.177
50	167.347263939 123.915863411	1 034746212	SIO2HL	1.56028900	77.713
5] 52	0.00000000	7 <b>9</b> 999373259 1 <b>0</b> 366030727	IMMERS	1.3700000	25.089
-	0.00000000		THMEKS	1.00000000	11.000
53	0.500000000	<b>a</b> .000000000		1.0000000,	11.000

## ASPHERIC CONSTANTS

SURF	ACE NO. 4	SURFACE NO. 34
к	0.0000	K 0.0000
C1	2.26522214e-007	C1 -4.23637017e-009
C2	-3.59236651e-011	C2 -3.29710303e-014
C3	2.92133725e-015	
C4	-3.77696824e-019	C3 -3.52756803e-018
		C4 -4.13266120e-023
C5	7.96388858e-024	C5 -2.16653880e-027
C6	3.91986385e-027	C6 2.27691141e-031
C7	-4.547113246-031	
C8	0.00000000e+000	C7 -8.70596013e-036
C9	0.00000000e+000	C8 0.0000000e+000
		C9 0.0000000e+000
SURF	ACE NO. 6	GUDELOE VO
K	0.0000	SURFACE NO. 41
Cl	-1.19063117e-007	
CZ	1.94138266e-011	. К 0.0000
		Cl 3.45855942e-009
C3	-1.81962009e-015	C2 5.47566277e-014
C4	2.25193097e-019	
C5	-2 25566558e-023	C3 -3.85610770e-018
C6	1.19237134e-027	C4 2.74041138e-023
		C5 1.86632362e-027
C7	-2.51584924e-032	C6 ~3.44742394e~032
C8	0.0000000e+000	C7 3.29571792e-038
C9	0.00000000e+000	
		C8 0.0000000e+000
SURF	ACE NO. 17	C9 0.0000000e+000
T."	0.0000	SURFACE NO. 43
K	0.0000	
C1	1.74375723e-011	K 0.0000
Ç2	-2.04139734e-014	-
C3	7.67666306e-019	C1 -3.55873802e-010
C4	-1.93715606e-023	C2 9.63322458e-014
		C3 -7.64415866e-019
Ç5	1.92834024e-027	C4 2.00153471e-023
C6	-7.02565837e-032	C5 -1.98329358e-027
C7	1.14576119e-036	
C8	0.00000000e+000	C6 5.52524526e-032
		C7 -4.80876507e-037
C9	0.0000000e+000	C8 0.0000000e+000
		C9 0.0000000e+000
SURF	ACE NO. 25	
ĸ	0.0000	SURFACE NO. 48
C1	-6.99705361e-008	
		K 0.0000
C2	-3.25537639e-012	C1 -2.25289484e-009
C3	-2.93013408e-016	C2 2.62711822e-013
C4	-9.17751598e-020	
C5	4.34261555e-023	C3 3.12883195e-018
C6	-1.01901896e-026	C4 -2.96009757e-022
		C5 1.93969203e-026
C7	1.42841266e-030	C6 -7.02702044e-031
Ç₿	0.00C0000Ce+0\$0	
C9	0.00000000e+000	C7 1.40339412e-035
		C8 0.00000000e+000
SUR	FACE NO. 29	C9 0.00000000e+000
к	0.0000	
C1	3.01663174e-005	
C2	-4.16186211e-012	
C3	-2.13017649e-017	
C4	1.39699846e-020	
C5	-1.51363159e-024	
C6	6.56920089a-029	
C7	-3.15414270e-033	
C8	0.00000000e+000	
C9	0.0000000e+000	
	2.0002000CT040	

Table 5

SURFAC	E RADII	MUT GYOTTE CE C	LENSES	REFRACTIVE INDEX	1/2 FREE
BURFAC	. KADII	THICKNESSES	ELHOCO .	???.??·nm	DIAMETER
0	0.000000000	21.580160000	L710	1.00000000	. 55.000
i	0.000000000	5.521159992	L710	1.00000000	59.973
2	-653.380153342	10.705637537	CAF2HL	1.55848720	60.652
3	234.866815376	14.192447066	HE193	1.00000000	64.672
4	-541,443785623AS	8.069018137	CAF2HL	1.55848720	66.216
5	809.887192810	22.060952617	HE193	1.0000000	70.663
6	437.017712375AS	16.935405940	CAF2HL	1.55848720	88.269
7	315.047933823	22.322216303	HE193 ·	1.0000000	94.661
8	-1055.166104070	68.241607282	CAF2HL	1.55848720	97.341
و	-440.417777767	1.950157109	HE193	1.00000000	124.495
10	-833.235756565	45.202958015	CAF2HL	1.55848720	130.520
11	-248.097167968	6.967867993	HE193	1.00000000	. 136.785
12	-667.629333865	58.527118374	CAF2HL	1.55848720	147.021
13	-230.265801432	1.000000000	HE193	1.00000000	152.069
14	-635.989091493	52.689533957	CAF2HL	1.55848720	151.782
15	-420.897980530	1.000000000	HE193	1.00000000	155.231
16	682.574050518	42.565469096	CAF2HL	1.55848720	150.819
17	-650.602325928AS	1.000000000	HE193	1.00000000	149.697
18	143.909393739	39.312156678	CAF2HL	1.55848720	
19	170.361039751	1.000000000	HE193	1.00000000	117.562
20	170.361633731	33.064705540	CAF2HL	1.55648720	106.663
21	149.757517850	27.658696477	HE193		99.558
21	893.404652749		CAF2HL	1.00000000	88.267
	85.474739309	8.000000000		1.55846720	85.687
23	-554:412838267	42.082501866	HE193	1.00000000	67.021
24 25	133.887772925A5	8.000000000 36.097576773	CAF2HL HE193	1.55848720	65.854
25 26	-202.032636775	8.000000000	· CAFZEL	1.00000000	€3.605
27	-136B.827229050	39.670298843	HE193	1.55848720 1.0000000	64.919
28	-87.722719327	8.150939605	CAF2HL	1.55848720	€8.993
25	-341.867554503AS	7.243142706	HE193	1.00000000	70.057
30	-270.393973331	34.812062471	CAF2HL	1.55848720	89.680
31	'-131.925970131	1.000000000	HE193	1.00000000	92.272 97.490
32	-356.379287278	37.218470508	CAF2HL	1.55848720	109.741
33	-160.486739217	1.000000000	HE193	1.00000000	113.010
34	728.417353927AS	44.411516365	CAF2HL	1.55848720	
35	-285.991760803	26,777077207	HE193	1.00000000	121.086
3.5	-169.413078236	8.000000000	CAF2HL	1.55848720	121.404
37	1233.439177430	5.704973599	HE193	1.00000000	120.698 135.519
38	1968.954811160	42.925033480	CAF2HL	1.55848720	136.862
39	-334.436426428	1.000000000	HE193	1.00000000	
40	448.482885926	53.515273929	CAF2HL	1.55848720	138.799
41	-481.778223591AS	38.864604302	HE193	1.00000000	145.983 145.641
42	-257.207339099	39.651511432	CAF2HL	1.55848720	141.395
43	-352.351244424AS	8.074724759	HE193	1.00000000	
44	0.000000000				146.219
	1571.538613070	8.135112666	HE193	1.00000000	142.806
45 46	-395.530190539	41.393617207	CAF2HL HE193	1.55848720	143.060
47	189.594554041	44.893603417	CAFZHL	1.55848720	142.883
4.7 4.8	737.40022072148	1.254530428	HE193	1.55848720	122.058
49	113.971025132		CAFZHL	1.55848720	117.739
50	186.560340242	34.168140572 1.000000000	HE193	1.00000000	91.979
51	124.935012572	92.227373544	CAF2HL		85.029
52	0.000000000			1.55848720	76.952
5 <i>2</i> 53	0.000000000	0.050000026	IMMERS	1.37000000	11.068
و د	0.00000000	0.000000000		1.00000000	11.000

#### ASPHERIC CONSTANTS

```
SURFACE NO. 34
SURFACE NO.
        7.3965
                                                 ĸ
                                                        3..5440
Сl
       2.19490389e-007
                                                 CJ
                                                        -3.43367330e-009
       -3.18478613e-011
                                                 C2
                                                        -1.34450662e-014
       2.656992410-015
                                                 C3
                                                        -2.29266384e-016
C4
C5
C6
      -3.54396715e-019
                                                 C4
C5
                                                        9.75729676e-023
       1.30925174e-023
2.26447806e-027
                                                        -1.35202712e-026
                                                 C6
                                                        8.80518329e-031
C7
      -2.544781296-031
                                                        -2.65068179e-035
Ca
       0.00000000e+000
                                                 CB
                                                        0.00000000e+000
       0.000000000+000
                                                 C9
                                                         0.00000000e+000
SURFACE NO.
                                                  SURFACE NO.
                                                               41
       0.6253
ĸ
                                                         0.0872
      -1.14294859e-007
Cl
                                                 C1
                                                         3.26909809e-009
       1.87842380c-011
                                                 C2
                                                         7.76009100e-014
C3
      -1.79164086e-015
                                                 C3
                                                        -3.82550397e-018
C4
C5
C6
       2.34304280e-019
                                                 C4
C5
C6
                                                        2.28007850e-023
      -2.31194495e-023
                                                        -2.34153651e-028
1.34376005e-032
       1.12536497e-027
C7
      -2.03074756e-032
                                                        -1.01621932e-036
                                                 C7
C6
       0.000000002+000
                                                         0.00000000e+000
       0.000000000+000
                                                 C9
                                                         0.00000000e+000
SURFACE NO.
             17 .
                                                  SURFACE NO. 43
K.
       0.7878
                                                        .0.0312
ď١
      -3.05430457e-010
                                                 C1
                                                        -4.99867832e-010
C2
      -4.89773138e-014
                                                 C2
                                                        1.15316140e-013
C3
       1.06923190e-018
                                                 СЗ
                                                        -1.41640795e-018
      -1.47516954e-023
                                                 C4
C5
C6
C7
                                                        7.05365641e-023
C5
       1.34357246e-027
                                                        -2.43649494e-027
C6
      -5.23906240e-032
                                                        6.83361566e-032
C7
       8.17069597e-D37
                                                        -6.25588420e-037
       0.0000000ce+000
C8
                                                 C8
                                                         0.00000000e+000
C9
       0.00000000de±000
                                                         0.00000000e+000
 SURFACE NO.
                                                  SURFACE NO.
                                                               48
к
       0.0013
                                                        -1.8716
Cl
      -6.90183181e-008
                                                        -4.01414746e-009
                                                 Cl
C2
      -2.08603493e-012
                                                        1.94301708e-013
                                                 CZ
C3
C4
C5
      -3.48958288e-016
                                                 C3
                                                         4.07775084e-018
      -3.58451964e-020
                                                 C4
                                                        -4.70574709e-022
       2.16254654e-023
                                                 C5
                                                         2.42642656e-026
      -3.98801026e-027
                                                 C6
                                                        -8.38949812e-031
       6.60002235e-031
                                                 C7
                                                         1.38189311e-035
Cö
       0.000000000+000
                                                 C8
                                                         0.00000000e+000
       0.000000000a+000
                                                         c.cc0000000e+000
                                                 C9
 SURFACE NO.
      -0.0334
       3.02609727=-003
Cl
      -3.89225347e-012
C3
      -2.10302538e-017
C4
       1.38850354e-020
C'5
      -1.75136022e-024
C€
C7
       9.451643890~029
      -4.34631621e-033
       0.00000000e+000
       C. 00000000000000
```

Table 7

SURFACE	RADII	THICKNESSES	LENSES	REFRACTIVE INDEX	1/2 FREE DIAMETER
0	0.000000000	21.980160000			55.000
i	0.00000000	5.694922030			59.974
2	-683.677092960	8.000016965	CAF2HL	1.55848720	60.653
3	241,804516194	13.492175419			64.06C
4	-561.327374916AS	8.000000000	CAFZHL	1.55848720	65.556
5	699.454774317	23.282413511			69.867
6	400.792577467AS	11.762291230	CAF2HL	1.55848720	88.232
7	293.294615517	22.385188600			92.839
8 -	1055.962319550	71.454892862	CAF2HL	1.55848720	95.242
9	-483.111728442	2.387926569			124.181
10	-967.495121648	48.847817148	CAF2HL	1.55848720	130.362
11	-235.898512938	5.659224997			136.444
12	-579.940954244	54.879651202	CAF2HL	1.55848720	145.324
13	-221.637621698	1.000000000			149.602
14	-775.372223325	15.081823940	CAF2HL	1.55848720	147.807
15	-525.919868017	1.000000000			148.157
16	660.302511324	38.720317303	CAF2HL	1.55848720	144.440
17	-732.46794=129AS	1.000300000			143.303
18	147.955956945	38.541140120	CAF2HL	1.55848720	116.315
19	174.954421407	1.000000000			105.360
20	118.333525649	33.404122786	CAF2HL	1.55846720	96.491
21	140.216192098	28.013496674			85.972
22	788.027919344	8.457239690	CAF2HL	1.55848720	83.494
23	83.038332631	41.178404325			65.374
24	-597.396381251	8.000000000	CAF2HL	1.55648720	64.284
25	136.956016017AS	31.536496068	G . C		62.327
26 27	-200.199292002 1650.730497600	8.000000000	CAF2HL	1.55848720	63.210
28		43.442178500	CARRIE	2 55546556	66.958
29	-86.362069271 -360.17945;570AS	8.210360232	CAF2HL	1.55848720	69.385
30	-280.601605332	2.567422592 34.872981631	CAF2HL	1.55848720	89.255
31	132.713942995	1.004709559	CAFZRL	1.55848720	92.027
32	-361.662148157	37.722697596	CAF2HL	1.55848720	97.215 109.325
33	-159.165877620	1.050000000	CAI ZILLI	1.33646720	112.571
34	750.946018427AS	43.541363913	CAF2HL	1.55848720	120.144
35	-285.806553705	25.930047100		2.33010720	120.440
36	-169.581349559	8.030377840	CAF2HL	1.55848720	119.789
37	1077.110485570	5.662989489			134.185
38	1605.653205960	43,332820801	CAF2HL	1.55848720	135.539
39	-333.794563037	1.000000000			137.425
40	448.584289713	52.027765048	CAF2HL	1.55848720	144.C43
41	-487.266144069AS	37.362834300			143.681
42	-256.080121302	40.279714930	CAF2HL	1.55848720	139.838
43	-353.759022671AS	7.564240001			144.656
44	0.600000000	10.832272687			141.334
45	1499.148900820	42.690870531	CAF2HL	155848720	141.660
46	-394.545474104	2.390581943			141.445
4?	188.988731298	43.117430646	CAF2HL	1.55848720	121.630
48	731.593986095AS	1.000000000			117.999
49	114.385993:39	33.926813476	CAF2HL	1.55848720	92.421
50	184.018635075	1.000000000			85.485
51	123.357013160	93.333990149	CAF2HL	1.55848720	77.332
52	0.00000000	0.050000000	Immersion	1.37000000	11.058
53	0.000000000	0.00000000			11.000

#### ASPHERIC CONSTANTS

6.0000000e+000

```
3.4
                                                 SURFACE NO.
SURFACE NO.
       2.4014
                                                        1.5943
                                                       -3.41875063e-009
-1.06207572e-014
       2.24623581e-007
                                                 C1
      -3.32~17029e-011
2.75111747e-015
                                                 C2
CZ
                                                        -2.75870187e-018
C3
C4
      -3.79340993e-019
                                                        1.25443795e-022
                                                 C5
                                                        -1.53842992e-026
C5
       1.61861324e-023
       2.155782776-027
                                                 C6
                                                        9.81335165e-031
C6
                                                        -2.88557010e-035
                                                 C7
      -2.81911737e-031
C7
                                                        0.00000000e+000
                                                 C8
СB
       0.000000000000000
                                                 C9
                                                        0.0000000c+000
C9
       0.00000000e+000
SURFACE NO.
                                                 SURFACE NO.
                                                        0.1099
       1.5259
                                                        3.24105758e-009
       -1.32174954e-007
                                                 Сĭ
Cl
                                                        7.37348572e-014
                                                 C2
C2
       1.85234618e-011
                                                        -3.58460435e-018
                                                 C3
C3
      -1.79384980e-015
2.32576675e-019
                                                        2.55537441e-023
C4
                                                 CS
                                                        -1.78486202e-028
      -2.32368876e-023
C5
                                                 C6
                                                        1.62622698e-032
C6
       1.17478944e-027
                                                        -1.16103266e-036
      -2.27644098e-032
                                                 C7
C7
                                                        0.00000000e+000
                                                 C8
C8
       0.00000000e+000
                                                 C9
                                                        0.00000000e+000
C9
       0.00000000e+000
                                                  SURFACE NO.
 SURFACE NO.
             :7
                                                 Κ
                                                        0.0331
K
       1.6238
                                                        -4.94661761e-010
Cl
      -4.04184504e-010
                                                 C1
                                                 C2
                                                        1.09503739e-013
CZ
      -5.52221230e-014
     1.07792813e-018
.-9.66577933e-024
                                                        -1.45124835e-018
CЗ
                                                 C3
                                                 C4
                                                        6.84809756e-023
C4
                                                 C5
                                                        -2.60450711e-027
       1.9318-487e-027
C5
      -7.97233584e-032
                                                 C6
                                                        7.57276741e-032
C6
                                                        -7.11474674e-037
C7
       1.33745628e-036
                                                 C7
                                                        C.00000000e+000
                                                 C.8
C8
       0.00003000e+000
                                                         G.90000000e+000
C9
       0.00000000e+000
                                                  SURFACE NO.
                                                               48
SURFACE NO.
              25
                                                 ĸ
                                                        -1.6262
       0.0096
                                                        -4.0008123Ge-009
                                                 Cl
Cl
      -6.73676580e-008
                                                 C2
                                                         1.92491101e-013
C2
      -2.66411173e-012
                                                 Ċ3
                                                         3.74976393e-018
C3
      -4.29360639e-016
                                                        -4.50566284e-022
      -8.53658144e-020
C4
C5
       3.61027613e-023
                                                 Ç5
                                                        2.41249474e-026
                                                 C6
                                                        -8.61661412e-031
C6
      -7.30829628e-027
                                                 C7
                                                         1.44171993e-035
C.7
       1.01538199e-030
                                                         0.00000000e+000
                                                 C.B
C8
       0.00000000e+000
                                                         0.00000C00e+000
C9
       0.00000000e+000
SURFACE NO.
              ::9
      -0.2765
C1
       3.115358636-008
C2
      -4.09777758e-012
Ç3
      -6.25050384e-018
       1.47181035e-020
C4
      -1.67736576e-024
C5
       7.46970419e-029
CE
C7
      -2.84/82511e-033
C6
       0.00000000e+000
```

Table 9

SURFACE	E RADII	THICKNESSES	LENSES	REFRACTIVE INDEX	1/2 FREE DIAMETER
0	0.000000000	21.980160000		1.00000000	56.080
2	0.000000000	1.246888384	L710	0.99998200	61.197
2	-7758.872975141	8.000000000	SIC2HL	1.56028900	61.896
3	355.78918:957	7.529172915	HE193	0.99971200	63.992
4	1890.369849162AS	8.000000000	SIO2HL	1.56028900	65.078
5	268.213281606	15,157771412	HE193	0.99971200	68.460
6	3183.174654849AS	8.000000000	SIO2HL	1.56028900	72.301
7	542.737427921	25.228019508	HE193	0.99971200	76.281
8	-190.186655474	54.303344531	SIO2HL	1.56028900	78.244
9	-200.972554549	1.000000000	HE193	0.99971200	102.934
10	-1181.739114120	41.618093168	SIO2HL	1.56028900	116.315
11	-200.99978,189	1.000000000	HE193	0.99971200	119.335
12	-345.801617038	34.756009233	SIO2HL	1.56028900	122.895
13	-183.C35949027	1.000000000	HE193	0.99971200	125.001
14	468.598304219	28.888366130	SIO2HL	1.56028900	119.583
15	-1579.330378954AS	1.000000000	HE193	0.99971200	118.410
16	130.622577421	25.607493426	SIO2HL	1.56028900	101.535
17	167.663753864	1.000000000	HE193	0.99971200	96.903
18	109.515010627	33.485629573	SIQ2HL	1.56028900	
19	139.897752059	27.284753341	HE193	0.99971200	88.871 79.284
20	8434.054206242	E.000000000	SIO2HL	1.56028900	
21	75.280373304	30.508120723	HE193	0.99971200	76.872 60.167
22	712.917049547		SIO2HL	1.56028900	
23	137.047990)49AS	8.000000000	HE193	0.99971200	59.980
24	-120.168131858	41.376149828	SIO2HL	1.56028900	58.756
25	-335.689995101	8.000000000 26.955101014	HE193	0.99971200	60.070 64.725
26	-86.294374443	E.405631441	SIO2HL	1.56028900	_
27	-401.2219"65/5AS	6.791819241	HE193	0.99971200	65.622
28	-295.528316934		SIO2HL	1.56028900	82.38 <i>6</i>
29	-156.311920654	33.017957091	HE193	0.99971200	84.761 93.276
30	-268.979127316	33.049041389	SIO2HL	1.56028900	99.716
31	-143.11632ay61	1.000000000	HE193	0.99971200	103.445
32	472.893981029AS	41.687451272	SIO2HL	1.56028900	115.709
33	-346.217421641	22.889302349	HE193	0.99971200	116.094
34	-187.601096847	12.645469238	SIO2HL	1.56028900	115.710
35	-359.852656461	1.000000000	HE193	0.99971200	121.777
36	722.017664882	60.459509481	SIO2HL	1.56028900	125.218
37	-1816.4327)1561AS	24.260456335	HE193	0.99971200	125.322
38	2199.280274610	24.178147653	SIO2HL	1.56028900	124.815
39	-1512.556722835	E.000000000	HE193	0.99971200	124.440
40	0.000000000	14.309578556	HE193	0.99971200	123.088
41	1738.196399601	35.559449287	SIO2HL	1.56028900	124.310
42	-429.627570104AS	1.000000000	HE193	0.99971200	124.510
43	179.589102742	59.687793359	SIO2HL	1.56028900	115.507
4.4	589.027987143AS	10.530033379	HE193	0.99971200	105.186
45	136.621156961	53.097791469	SIO2HL	1.56028900	89.320
46	130.621156561	1.000000000	HE193	0.99971200	67.001
47	93,326477153		S102HL	1.56028900	62.339
		90.505495277	IMMERS	1.56000000	
4.8	0.000000000	1.000000545	Transks		14.735
49	0.000000000	0.00000000		1.00000000	14.020

#### ASPHERIC CONSTANTS

#### SURFACE NO. 0.0000 C1 2.81531001e-007 C2 -3.99703415e-011 С3 2.76850090e-015 -4.54867122e-019 -5.66904777e-024 C4 C5 C6 C7 5.03662466c-027 -4.520E0360e-031 C٤ 0.00000000e+000 CЭ 0.00000000e+000 SURFACE NO. 0.0000 -1.16706261e-007 Ç1

C1 -1.16706261e-007
C2 2.00348321e-011
C3 -1.51130378e-015
C4 3.09660955e-019
C5 -1.78658953e-023
C6 3.15835636e-027
C7 -4.23595936e-031
C6 0.0000000e+000
C9 0.0000000e+000

### SURFACE NO. 15

K 0.0000 C1 -9.37524970e-010 C2 -2.58161066e-013 C3 -5.12306559e-018 C4 1.80598481e-022 C5 3.605398C0e-027 C6 3.85878819e-031 C7 -3.50559744e-037 C8 0.0000000e+000 C9 0.0000000e+000

#### SURFACE NO. 23

0.0000 -9.05676602e-008 Cl C2 -7.64727914e-013 C3 -9.31867049e-016 C4 9.20035750e-020 C5 -9.15433014e-023 C٤ 1.32736186e-026 C7 -9.23872382e-031 CB 0.00000000e+000 C9 0.00000000e+000

#### SURFACE NO. 27

0.0000 2.51519254e-008 Cl -4.,37829106e-012 C3 2.66987386e-017 1.45024261e-020 -1.31152094e-024 C4 C5 1.04657156e-030 CG C7 -9.21174949e-034 0.00000000e+000 СS 0 00000000e+000

#### SURFACE NO. 32

K 0.0000 C1 -2.59168418e-009 C2 -8.93760219e-014 C3 -4.25486946e-018 C4 3.13097668e-022 C5 -1.87333640e-026 C6 1.28572875e-035 C7 -3.94471730e-035 C8 0.0000000e+000

#### SURFACE NO. 37

K 0.0000
C1 3.92265908e-009
C2 5.90432031e-014
C3 -4.61273256e-018
C4 5.09437288e-023

## Patent Claims

- 1. Refractive projection objective for projecting a pattern arranged in an object plane of the projection objective into an image plane of the projection objective with the aid of an immersion medium which is arranged between a last optical element of the projection objective and the image plane, comprising:
- a first lens group (LG1), following the image plane, with a negative refracting power;
- a second lens group (LG2), following the first lens group, with a positive refracting power;
- a third lens group (LG3), following the second lens group, with a negative refracting power;
- a fourth lens group (LG4), following the third lens group, with a positive refracting power;
- a fifth lens group (LG5), following the fourth lens group, with a positive refracting power; and
- a system aperture (5) which is arranged in the region of maximum beam diameter between the fourth and the fifth lens group.
- 2. Projection objective according to Claim 1, wherein the system aperture (5) lies between a plane of maximum beam diameter near the image and the image plane (3).
- 3. Projection objective according to Claim 1 or 2 which has an imageside numerical aperture  $NA \ge 0.9$ , the image-side numerical aperture preferably being at least NA = 1.0.
- 4. Projection objective according to one of the preceding claims, wherein the projection objective is adapted to an immersion medium (10) which has a refractive index of n > 1.3 at the operating wavelength.

- 5. Projection objective according to one of the preceding claims, wherein the projection objective has an image-side working distance of between approximately 10  $\mu$ m and approximately 200  $\mu$ m, in particular between approximately 20  $\mu$ m and approximately 100  $\mu$ m.
- 6. Projection objective according to one of the preceding claims, wherein a ratio between the focal length of the fourth lens group (LG4) and the focal length of the fifth lens group (LG5) is between approximately 0.9 and approximately 1.1.
- 7. Projection objective according to one of the preceding claims, wherein a ratio of the magnitudes of the focal lengths of the first lens group (LG1) and the fifth lens group (LG5) is between approximately 0.7 and approximately 1.3, in particular between approximately 0.9 and approximately 1.1.
- 8. Projection objective according to one of the preceding claims, wherein a ratio between the overall length of the projection objective and the focal length of the fifth lens group (LG5) is greater than five, preferably greater than six, in particular greater than eight.
- 9. Projection objective according to one of the preceding claims, wherein the first lens group (LG1) includes at least one aspheric surface, two aspheric surfaces preferably being provided in the first lens group.
- 10. Projection objective according to one of the preceding claims, wherein at least one aspheric surface is provided in the third lens group (LG3), two aspheric surfaces preferably being provided.
- 11. Projection objective according to one of the preceding claims, wherein at least one aspheric surface is arranged in the first lens group,

and/or wherein not more than nine aspheric surfaces are provided, less than seven aspheric surfaces preferably being provided.

- 12. Projection objective according to one of the preceding claims, wherein at least one meniscus lens (13), convex relative to the object plane, with a negative refracting power is arranged in the near zone of the object plane (2), in particular inside the first lens group (LG1).
- 13. Projection objective according to one of the preceding claims, wherein the second lens group has at least four, preferably at least five or six consecutive lenses (14 to 20) with a positive refracting power.
- 14. Projection objective according to one of the preceding claims, wherein the second lens group (LG2) has at least one, preferably a plurality of meniscus lenses (14, 15, 16, 17), concave relative to the object plane, with a positive refracting power on an entry side facing the object plane (2), and/or wherein the second lens group has at least one, preferably a plurality of meniscus lenses (19, 20), convex relative to the object plane, with a positive refracting power on the exit side facing the image plane.
- 15. Projection objective according to one of the preceding claims, wherein the second lens group (LG2) in this sequence has at least one meniscus lens (14, 15, 16, 17), concave relative to the object plane, with a positive refracting power, a biconvex positive lens (18) and at least one meniscus lens (19, 20), concave relative to the image plane, with a positive refracting power.
- 16. Projection objective according to one of the preceding claims, wherein the third lens group (LG3) has only lenses (21, 22, 23, 24) with a negative refracting power.

- 17. Projection objective according to one of the preceding claims, wherein, with reference to a plane (9) of symmetry lying inside the third lens group (LG3), the third lens group is of substantially symmetrical construction, and/or wherein two oppositely curved, concave surfaces directly opposed to one another in the third lens group (LG3) and are surrounded by two concave surfaces which are concave relative to one another.
- 18. Projection objective according to one of the preceding claims, wherein an exit region, facing the third lens group (LG3), of the second lens group (LG2), and an entry region, following the third lens group, of the fourth lens group (LG4) are constructed substantially symmetrically relative to a plane (9) of symmetry lying inside the third lens group.
- 19. Projection objective according to one of the preceding claims, wherein the fourth lens group (LG4) has at least one doublet (27, 28, 29, 30) with a biconvex positive lens (27, 29) and a downstream negative meniscus lens (28, 30) with lens surfaces which are concave towards the object, at least two doublets preferably being provided.
- 20. Projection objective according to one of the preceding claims, wherein in an object-side entry region the fourth lens group (LG4) has at least one meniscus lens (25, 26), concave relative to the object plane (2), with a positive refracting power, a plurality of such meniscus lenses preferably being provided consecutively.
- 21. Projection objective according to one of the preceding claims, wherein the sine of the maximum incidence angle of the radiation impinging on the optical surfaces is less than 90%, in particular less than 85% of the image-side numerical aperture.

- 22. Projection objective according to one of the preceding claims, wherein the fifth lens group (LG5) has exclusively lenses with a positive refracting power.
- 23. Projection objective according to one of the preceding claims, wherein the fifth lens group has at least four positive lenses (31 to 35).
- 24. Projection objective according to one of the preceding claims, wherein the fifth lens group (LG5) has at least one meniscus lens (33, 34) with a positive refracting power and lens surfaces concave towards the image.
- 25. Projection objective according to one of the preceding claims, wherein as last optical element the fifth lens group (LG5) has a planoconvex lens (35) which preferably has a spherical entry surface and a substantially flat exit surface.
- 26. Projection objective according to Claim 25, wherein the planoconvex lens (35) is constructed in a nonhemispherical fashion.
- 27. Projection objective according to one of the preceding claims, wherein all the lenses consist of the same material, use preferably being made of synthetic quartz glass as lens material for a 193 nm operating wavelength, and/or of calcium fluoride as lens material for a 157 nm wavelength.
- 28. Projection objective according to one of the preceding claims which is a single-waist system with a belly (6) near the object, a belly (8) remote from the object and a waist (7) therebetween.
- 29. Projection objective according to one of the preceding claims, wherein the image field diameter is more than 10 mm, in particular more

than 20 mm and/or wherein the image field diameter is more than 1.0%, in particular more than 1.5%, of the overall length.

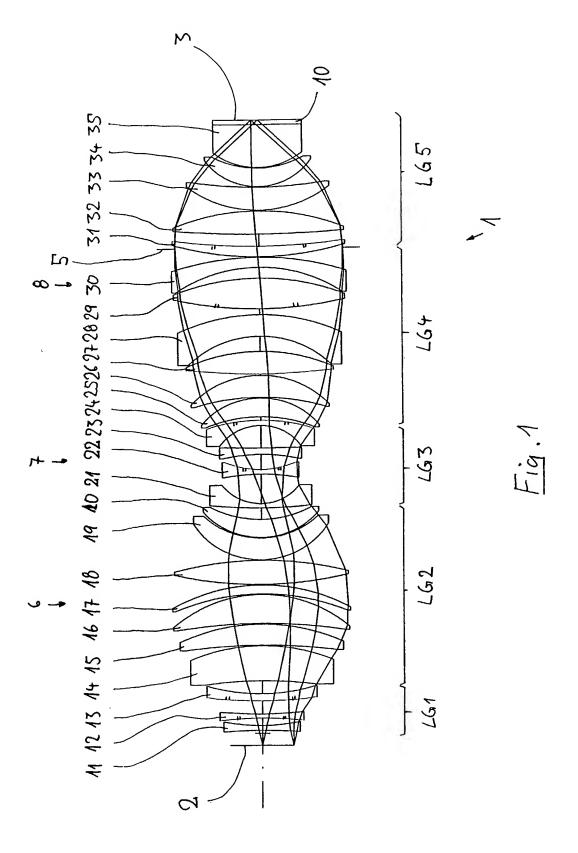
- 30. Projection objective according to one of the preceding claims, wherein the light conductance is more than approximately 1%, in particular more than approximately 2% of the overall length.
- 31. Projection objective according to one of the preceding claims, wherein substantially more lenses are arranged upstream of the system aperture (5) than downstream of the system aperture, preferably at least four times as many.
- 32. Projection objective according to one of the preceding claims, wherein at least five lenses with a positive refracting power are arranged between the waist and the system aperture (5).
- 33. Projection objective according to one of the preceding claims, wherein a distance between the waist and the system aperture is at least 26% of the overall length, preferably more than 30% of the overall length.
- 34. Projection objective according to one of the preceding claims, wherein a maximum rim ray height is at least twice as large as the rim ray height at the location of the narrowest constriction.
- 35. Projection exposure machine for microlithography, characterized by a refractive projection objective (1, 1', 1") in accordance with one of the preceding claims.
- 36. Method for producing semiconductor components and other finely structured structural elements, having the following steps: providing a mask with a prescribed pattern;

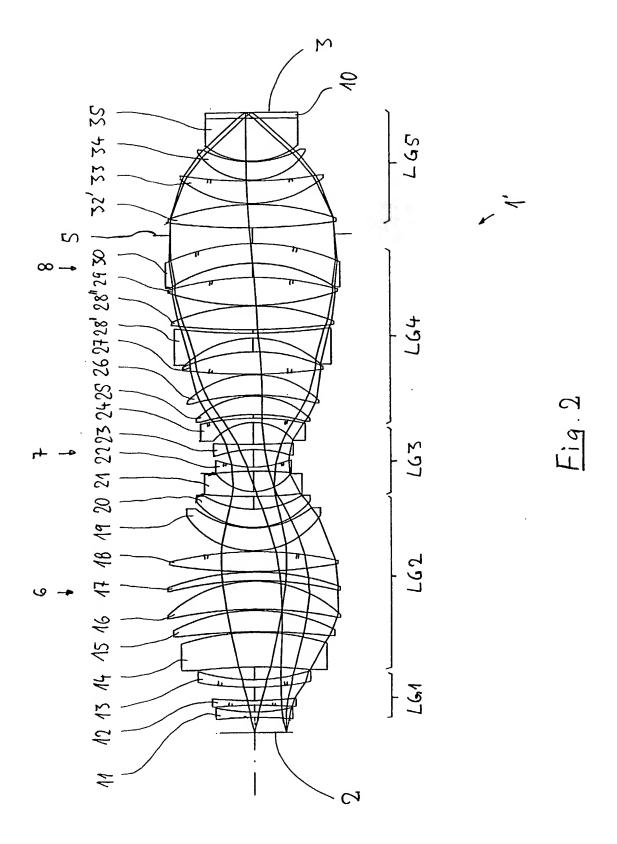
illuminating the mask with ultraviolet light of a prescribed wavelength; and

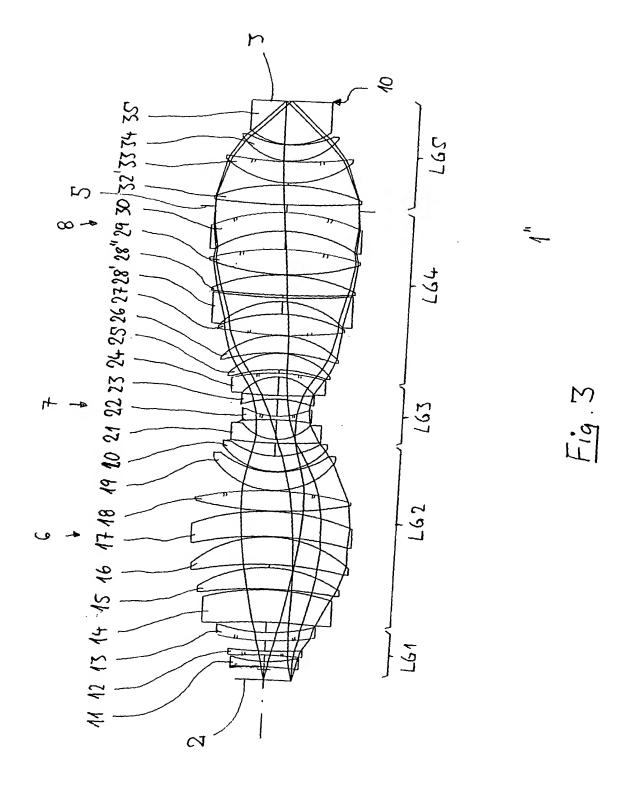
projecting an image of the pattern onto a photosensitive substrate, arranged in the region of the image plane of a projection objective, with the aid of a projection objective in accordance with one of the preceding Claims 1 to 34;

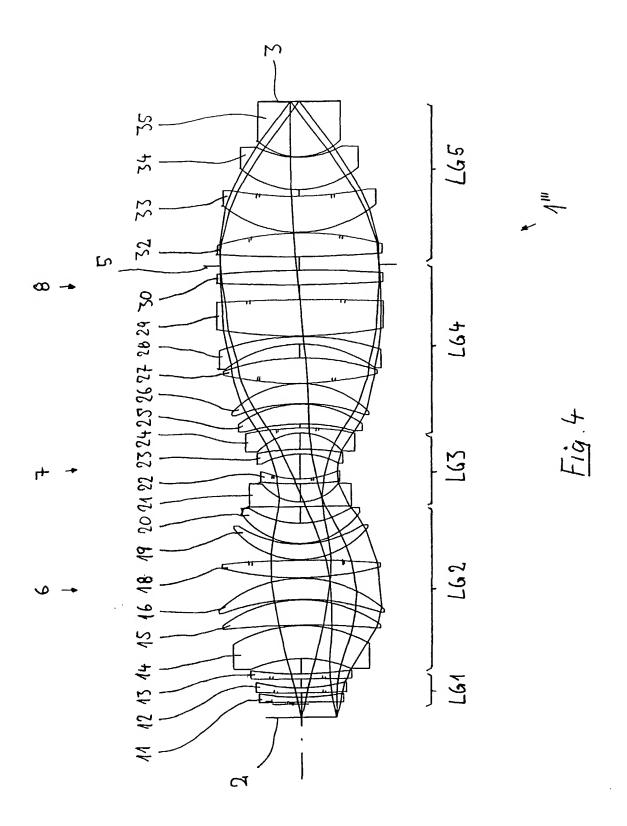
an immersion medium arranged between a last optical surface of the projection objective and the substrate being transilluminated during the projection.

. .









## INTERNATIONAL SEARCH REPORT

PCT/EP 03/01954

A. CLASSII	FICATION OF SUBJECT MATTER								
IPC 7 G03F7/20									
According to International Patent Classification (IPC) or to both national classification and IPC									
B. FIELDS									
	cumentation searched (classification system followed by classificati	on symbols)							
IPC 7	G03F		•						
Documentat	ion searched other than minimum documentation to the extent that s	such documents are included in the fields se	earched						
Clasticals d	ata base consulted during the international search (name of data ba	so and, where practical search terms used	`						
		Se and, where practical, search terms used	,						
EPO-In	ternai								
C. DOCUME	ENTS CONSIDERED TO BE RELEVANT								
Category °	Citation of document, with indication, where appropriate, of the re-	levant passages	Relevant to claim No.						
γ	EP 0 023 231 A (TABARELLI WERNER	W DR)	1-36						
	4 February 1981 (1981-02-04)								
	the whole document								
\ <i>\</i>	WALLATA IL ET AL. MEADDICATION OF	0 2 MM	1-36						
Υ	KAWATA H ET AL: "FABRICATION OF FINE PATTERNS USING OPTICAL PROJECT OF TRANSPORTED IN THE PROJECT OF THE PROJEC		1-30						
	LITHOGRAPHY WITH AN OIL IMMERSION								
	JAPANESE JOURNAL OF APPLIED PHYS								
	PUBLICATION OFFICE JAPANESE JOURN	NALÍOF							
	APPLIED PHYSICS. TOKYO, JP,								
	vol. 31, no. 12B, PART 1,								
	1 December 1992 (1992–12–01), pag 4174–4177, XP000415418	ges							
	ISSN: 0021-4922								
	abstract								
	<del>-</del>	-/ <del></del>							
X Furti	ner documents are listed in the continuation of box C.	Patent family members are listed	in annex.						
° Special ca	tegories of cited documents :	'T' later document published after the inte	ernational filing date						
	ent defining the general state of the art which is not lered to be of particular relevance	or priority date and not in conflict with cited to understand the principle or th							
'E' earlier o	document but published on or after the international	invention "X" document of particular relevance; the o	claimed invention						
filing d	late ant which may throw doubts on priority claim(s) or	cannot be considered novel or canno involve an inventive step when the do	t be considered to						
which is cited to establish the publication date of another citation or other special reason (as specified)  "Y" document of particular relevance; the claimed invention cannot be considered to involve an inventive step when the									
O' docume	ent referring to an oral disclosure, use, exhibition or	document is combined with one or moments, such combination being obvio	ore other such docu-						
other i	ent published prior to the international filing date but	in the art.	•						
	nan the priority date claimed	"&" document member of the same patent	<del></del>						
Date of the	actual completion of the International search	Date of mailing of the international se	агон героп						
2	5 July 2003	01/08/2003							
Name and r	nailing address of the ISA	Authorized officer							
	European Patent Office, P.B. 5818 Patentlaan 2 NL – 2280 HV Rijswijk								
	Tel. (+31-70) 340-2040, Tx. 31 651 epo nl, Fax: (+31-70) 340-3016	Daffner, M							

## INTERNATIONAL SEARCH REPORT

Application No PCT/EP 03/01954

	PC1/EP 03/01954
ation) DOCUMENTS CONSIDERED TO BE RELEVANT	
Citation of document, with indication, where appropriate, of the relevant passages	Relevant to claim No.
KAWATA H ET AL: "OPTICAL PROJECTION LITHOGRAPHY USING LENSES WITH NUMERICAL APERTURES GREATER THAN UNITY" MICROELECTRONIC ENGINEERING, ELSEVIER PUBLISHERS BV., AMSTERDAM, NL, vol. 9, no. 1 - 4, 1 May 1989 (1989-05-01), pages 31-36, XP000034346 ISSN: 0167-9317 the whole document	1-36
EP 1 139 138 A (NIPPON KOGAKU KK) 4 October 2001 (2001-10-04) abstract; figures 1,2,10-14; tables 1-11	1-36
EP 1 094 350 A (ZEISS CARL ;ZEISS STIFTUNG (DE)) 25 April 2001 (2001-04-25) abstract; figure 1; table 1	1-36
ULRICH W ET AL: "TRENDS IN OPTICAL DESIGN OF PROJECTION LENSES FOR UV-AND EUV-LITHOGRAPHY" PROCEEDINGS OF THE SPIE, SPIE, BELLINGHAM, VA, US, vol. 4146, 3 August 2000 (2000-08-03), pages 13-24, XP008016224 the whole document	1-36
US 2002/005938 A1 (OMURA YASUHIRO) 17 January 2002 (2002-01-17) abstract; figures 7,9	1-36
US 5 121 256 A (MANSFIELD SCOTT M ET AL) 9 June 1992 (1992-06-09) the whole document	1-36
	KAWATA H ET AL: "OPTICAL PROJECTION LITHOGRAPHY USING LENSES WITH NUMERICAL APERTURES GREATER THAN UNITY" MICROELECTRONIC ENGINEERING, ELSEVIER PUBLISHERS BV., AMSTERDAM, NL, vol. 9, no. 1 - 4, 1 May 1989 (1989-05-01), pages 31-36, XP000034346 ISSN: 0167-9317 the whole document  EP 1 139 138 A (NIPPON KOGAKU KK) 4 October 2001 (2001-10-04) abstract; figures 1,2,10-14; tables 1-11  EP 1 094 350 A (ZEISS CARL; ZEISS STIFTUNG (DE)) 25 April 2001 (2001-04-25) abstract; figure 1; table 1  ULRICH W ET AL: "TRENDS IN OPTICAL DESIGN OF PROJECTION LENSES FOR UV-AND EUV-LITHOGRAPHY" PROCEEDINGS OF THE SPIE, SPIE, BELLINGHAM, VA, US, vol. 4146, 3 August 2000 (2000-08-03), pages 13-24, XP008016224 the whole document  US 2002/005938 A1 (OMURA YASUHIRO) 17 January 2002 (2002-01-17) abstract; figures 7,9  US 5 121 256 A (MANSFIELD SCOTT M ET AL) 9 June 1992 (1992-06-09)

## INTERNATIONAL SEARCH REPORT

initiation on patent family members

Application No PCT/EP 03/01954

Patent document cited in search report		Publication date	•	Patent family member(s)		Publication date
EP 0023231	A	04-02-1981	EP AT DE	0023231 1462 2963537	T	04-02-1981 15-08-1982 07-10-1982
EP 1139138	Α	04-10-2001	WO EP WO WO TW	0123933 1139138 0123935 0123934 418343	A1 A1 A1	05-04-2001 04-10-2001 05-04-2001 05-04-2001 11-01-2001
EP 1094350	A	25-04-2001	EP JP TW US	1094350 2001141995 451076 6560031	A B	25-04-2001 25-05-2001 21-08-2001 06-05-2003
US 2002005938	A1	17-01-2002	JP	2001343582	Α	14-12-2001
US 5121256	Α	09-06-1992	NONE		<i></i>	